



(11) **EP 3 950 777 A1**

(12) **EUROPEAN PATENT APPLICATION**
published in accordance with Art. 153(4) EPC

(43) Date of publication:
09.02.2022 Bulletin 2022/06

(21) Application number: **20782206.5**

(22) Date of filing: **26.03.2020**

(51) International Patent Classification (IPC):
C08G 65/336 ^(2006.01) **C09D 5/16** ^(2006.01)
C09D 171/00 ^(2006.01) **C09K 3/18** ^(2006.01)

(52) Cooperative Patent Classification (CPC):
C08G 65/336; C09D 5/16; C09D 171/00; C09K 3/18

(86) International application number:
PCT/JP2020/013783

(87) International publication number:
WO 2020/203681 (08.10.2020 Gazette 2020/41)

(84) Designated Contracting States:
AL AT BE BG CH CY CZ DE DK EE ES FI FR GB GR HR HU IE IS IT LI LT LU LV MC MK MT NL NO PL PT RO RS SE SI SK SM TR
Designated Extension States:
BA ME
Designated Validation States:
KH MA MD TN

(30) Priority: **29.03.2019 JP 2019066338**

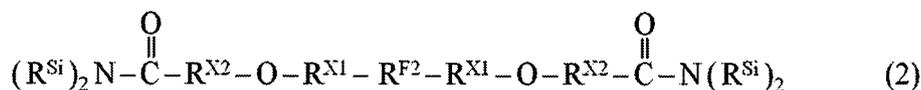
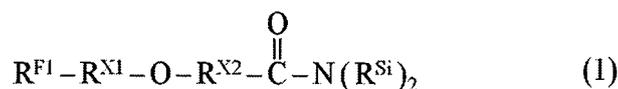
(71) Applicant: **DAIKIN INDUSTRIES, LTD.**
Osaka-shi, Osaka 530-8323 (JP)

(72) Inventors:
• **YAMASHITA, Tsuneo**
Osaka-shi, Osaka 530-8323 (JP)
• **MITSUHASHI, Hisashi**
Osaka-shi, Osaka 530-8323 (JP)
• **MAEHIRA, Takeshi**
Osaka-shi, Osaka 530-8323 (JP)
• **MOTONARI, Yoshimi**
Osaka-shi, Osaka 530-8323 (JP)

(74) Representative: **Hoffmann Eitle**
Patent- und Rechtsanwälte PartmbB
Arabellastraße 30
81925 München (DE)

(54) **FLUOROPOLYETHER GROUP-INCLUDING COMPOUND**

(57) A fluoropolyether group-containing compound of formula (1) or (2). [The symbols are as defined in the description.]



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Description

Technical Field

5 **[0001]** The present disclosure relates to a fluoropolyether group-containing compound.

Background Art

10 **[0002]** Certain types of fluorine-containing silane compounds are known to be capable of providing excellent water-repellency, oil-repellency, antifouling properties, and the like when used in surface treatment of a substrate. A layer obtained from a surface-treating agent containing a fluorine-containing silane compound (hereinafter, also referred to as a "surface-treating layer") is applied as a so-called functional thin film to a large variety of substrates such as glass, plastics, fibers, and building materials.

15 **[0003]** A known such fluorine-containing compound is a fluoropolyether group-containing silane compound having a fluoropolyether group in the molecular backbone and a hydrolyzable group bonding to a Si atom at the molecular terminal or in the terminal part (Patent Literature 1).

Prior Art Literature

20 Patent Literature

[0004] Patent Literature 1: JP 2000-327772 A

Summary of Invention

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Technical Problem

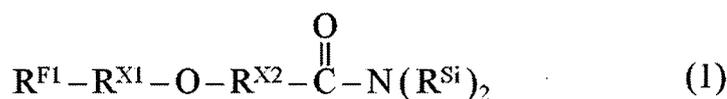
[0005] The surface-treating layer as described above may be required to have better friction durability.

30 Solution to Problem

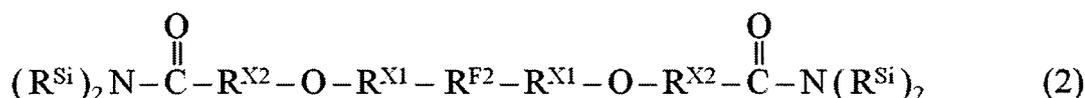
[0006] The present disclosure provides [1] to [14] below.

[1] A fluoropolyether group-containing compound of formula (1) or (2) below:

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40



45

wherein

R^{F1} is $\text{Rf}^1-\text{R}^{\text{F}}-\text{O}_{\text{q}}^-$;

R^{F2} is $-\text{Rf}^2_{\text{p}}-\text{R}^{\text{F}}-\text{O}_{\text{q}}^-$;

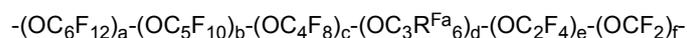
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Rf^1 is a C_{1-16} alkyl group optionally substituted with one or more fluorine atoms;

Rf^2 is a C_{1-6} alkylene group optionally substituted with one or more fluorine atoms;

R^{F} is each independently at each occurrence a group represented by formula:

55



a, b, c, d, e, and f are each independently an integer of 0 to 200, and the sum of a, b, c, d, e, and f is 1 or more, and the occurrence order of each repeating unit enclosed in parentheses provided with a, b, c, d, e, or f is not limited in the formula;

R^{Fa} is each independently at each occurrence a hydrogen atom, a fluorine atom, or a chlorine atom;

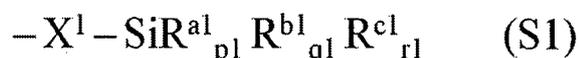
p is 0 or 1;

q is independently 0 or 1;

R^{X1} is each independently at each occurrence a C₁₋₆ alkylene group;

R^{X2} is each independently at each occurrence a C₁₋₆ alkylene group optionally substituted with a C₁₋₆ alkyl group or cyclic alkyl group optionally containing one or more nitrogen atoms, oxygen atoms, sulfur atoms, or silicon atoms, or with a perfluoroalkyl group;

R^{Si} is each independently at each occurrence represented by formula (S1) below:



X¹ is each independently at each occurrence a single bond, an oxygen atom, or a divalent organic group;

R^{a1} is each independently at each occurrence -Z¹-SiR^{a1'}_{p1'}R^{b1'}_{q1'}R^{c1'}_{r1'};

Z¹ is each independently at each occurrence a single bond, an oxygen atom, or a divalent organic group;

R^{a1''} is each independently at each occurrence -Z^{1''}-SiR^{a1''}_{p1''}R^{b1''}_{q1''}R^{c1''}_{r1''};

Z^{1''} is each independently at each occurrence a single bond, an oxygen atom, or a divalent organic group;

R^{a1'''} is each independently at each occurrence -Z^{1'''}-SiR^{a1'''}_{p1'''}R^{b1'''}_{q1'''}R^{c1'''}_{r1'''};

Z^{1'''} is each independently at each occurrence a single bond, an oxygen atom, or a divalent organic group;

R^{b1''''} is each independently at each occurrence a hydroxyl group or a hydrolyzable group;

R^{c1''''} is each independently at each occurrence a hydrogen atom or a monovalent organic group;

q^{1''''} is each independently at each occurrence an integer of 0 to 3;

r^{1''''} is each independently at each occurrence an integer of 0 to 3;

R^{b1''} is each independently at each occurrence a hydroxyl group or a hydrolyzable group;

R^{c1''} is each independently at each occurrence a hydrogen atom or a monovalent organic group;

p^{1''} is each independently at each occurrence an integer of 0 to 3;

q^{1''} is each independently at each occurrence an integer of 0 to 3;

r^{1''} is each independently at each occurrence an integer of 0 to 3;

R^{b1'} is each independently at each occurrence a hydroxyl group or a hydrolyzable group;

R^{c1'} is each independently at each occurrence a hydrogen atom or a monovalent organic group;

p^{1'} is each independently at each occurrence an integer of 0 to 3;

q^{1'} is each independently at each occurrence an integer of 0 to 3;

r^{1'} is each independently at each occurrence an integer of 0 to 3;

R^{b1} is each independently at each occurrence a hydroxyl group or a hydrolyzable group;

R^{c1} is each independently at each occurrence a hydrogen atom or a monovalent organic group;

p¹ is each independently at each occurrence an integer of 0 to 3;

q¹ is each independently at each occurrence an integer of 0 to 3;

r¹ is each independently at each occurrence an integer of 0 to 3; and

at least one R^{b1}, R^{b1'}, R^{b1''}, or R^{b1''''} is present for each group represented by R^{Si}.

[2] The fluoropolyether group-containing compound according to [1], wherein p is 0, and q₁ is 2 or 3.

[3] The fluoropolyether group-containing compound according to [1] or [2], wherein R^{Fa} is a fluorine atom.

[4] The fluoropolyether group-containing compound according to any one of [1] to [3], wherein X¹ is each independently at each occurrence a divalent organic group.

[5] The fluoropolyether group-containing compound according to any one of [1] to [4], wherein X¹ is each independently at each occurrence -(Z²¹)_{z11}-(X²)_{z12}-(Z²²)_{z13}- wherein Z²¹ and Z²² are a divalent organic group;

X² is an oxygen atom;

z₁₁ is 0 or 1;

z₁₂ is 0 or 1;

z₁₃ is 0 or 1; and

at least one of z₁₁ and z₁₃ is 1.

[6] The fluoropolyether group-containing compound according to any one of [1] to [5], wherein X¹ is each independently at each occurrence an alkylene group.

[7] A surface-treating agent comprising the fluoropolyether group-containing compound according to any one of [1] to [6].

[8] The surface-treating agent according to [7], further comprising one or more other components selected from a fluorine-containing oil, a silicone oil, and a catalyst.

[9] The surface-treating agent according to [7] or [8], further comprising a solvent.

[10] The surface-treating agent according to any one of [7] to [9], which is used as an antifouling coating agent or a water-proof coating agent.

[11] The surface-treating agent according to any one of [7] to [10], which is for vacuum deposition.

[12] A pellet comprising the surface treatment agent according to any one of [7] to [10].

[13] An article comprising a substrate and a layer on a surface of the substrate, wherein the layer is formed of the compound according to any one of [1] to [6] or the surface-treating agent according to any one of [7] to [11].

[14] The article according to [13], which is an optical member.

Advantageous Effect of Invention

[0007] According to the present disclosure, a fluoropolyether group-containing compound usable in the formation of a surface-treating layer having better friction durability can be provided.

Description of Embodiments

[0008] The term "monovalent organic group" as used herein represents a carbon-containing monovalent group. The monovalent organic group is not limited, and may be a hydrocarbon group or a derivative thereof. A derivative of a hydrocarbon group means a group having one or more of N, O, S, Si, amide, sulfonyl, siloxane, carbonyl, carbonyloxy, and the like at the terminal or in the molecular chain of the hydrocarbon group.

[0009] The "divalent organic group" as used herein is not limited, and examples include a divalent group obtained by removing one more hydrogen atom from the hydrocarbon group.

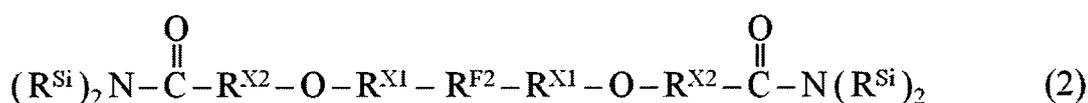
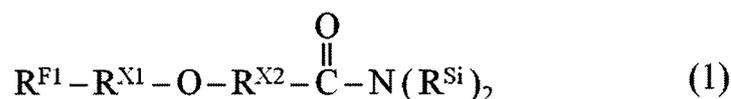
[0010] The term "hydrocarbon group" as used herein represents a group that contains carbon and hydrogen and that is obtained by removing one hydrogen atom from a molecule. The hydrocarbon group is not limited, and examples include a hydrocarbon group that has 1 to 20 carbon atoms and that is optionally substituted with one or more substituents, such as an aliphatic hydrocarbon group and an aromatic hydrocarbon group. The "aliphatic hydrocarbon group" may be either straight, branched, or cyclic, and may be either saturated or unsaturated. The hydrocarbon group may contain one or more ring structures. The hydrocarbon group may have one or more of N, O, S, Si, amide, sulfonyl, siloxane, carbonyl, carbonyloxy, and the like at the terminal or in the molecular chain thereof.

[0011] The substituent of the "hydrocarbon group" as used herein is not limited, and examples include one or more groups selected from a halogen atom, and a C₁₋₆ alkyl group, a C₂₋₆ alkenyl group, a C₂₋₆ alkynyl group, a C₃₋₁₀ cycloalkyl group, a C₃₋₁₀ unsaturated cycloalkyl group, a 5 to 10-membered heterocyclyl group, a 5 to 10-membered unsaturated heterocyclyl group, a C₆₋₁₀ aryl group, and a 5 to 10-membered heteroaryl group each optionally substituted with one or more halogen atoms.

[0012] Herein, the alkyl group and the phenyl group may be substituted or unsubstituted, unless specified otherwise. A substituent of such a group is not limited, and examples include one or more groups selected from a halogen atom, a C₁₋₆ alkyl group, a C₂₋₆ alkenyl group, and a C₂₋₆ alkynyl group.

[0013] The term "hydrolyzable group" as used herein represents a group which is able to undergo a hydrolysis reaction, i.e., represents a group that can be removed from the main backbone of a compound by a hydrolysis reaction. Examples of the hydrolyzable group include -OR^h, -OCOR^h, -O-N=CR^h₂, -NR^h₂, -NHR^h, and halogen (in these formulae, R^h represents a substituted or unsubstituted C₁₋₄ alkyl group).

[0014] The fluoropolyether group-containing compound of the present disclosure is a compound represented by formula (1) or (2) below:



[0015] In formula (1), R^{F1} is each independently at each occurrence R^{F1}-R^F-O_q-.

[0016] In formula (2), R^{F2} is -R^{f2}_p-R^F-O_q-.

[0017] In the formula, R^{f1} is each independently at each occurrence a C₁₋₁₆ alkyl group optionally substituted with one or more fluorine atoms.

5 [0018] The "C₁₋₁₆ alkyl group" as in the C₁₋₁₆ alkyl group optionally substituted with one or more fluorine atoms may be straight or branched, and is preferably a straight or branched C₁₋₆ alkyl group and in particular C₁₋₃ alkyl group, and more preferably a straight C₁₋₆ alkyl group and in particular C₁₋₃ alkyl group.

[0019] R^{f1} is preferably a C₁₋₁₆ alkyl group substituted with one or more fluorine atoms, more preferably a CF₂H-C₁₋₁₅ perfluoroalkylene group, and even more preferably a C₁₋₁₆ perfluoroalkyl group.

10 [0020] The C₁₋₁₆ perfluoroalkyl group may be straight or branched, and is preferably a straight or branched C₁₋₆ perfluoroalkyl group and in particular C₁₋₃ perfluoroalkyl group, more preferably a straight C₁₋₆ perfluoroalkyl group and in particular C₁₋₃ perfluoroalkyl group, and specifically -CF₃, -CF₂CF₃, or -CF₂CF₂CF₃.

[0021] In the formula, R^{f2} is a C₁₋₆ alkylene group optionally substituted with one or more fluorine atoms.

15 [0022] The "C₁₋₆ alkylene group" as in the C₁₋₆ alkylene group optionally substituted with one or more fluorine atoms may be straight or branched, and is preferably a straight or branched C₁₋₃ alkylene group, and more preferably a straight C₁₋₃ alkylene group.

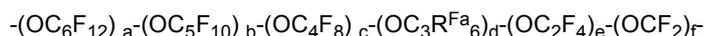
[0023] R^{f2} is preferably a C₁₋₆ alkylene group substituted with one or more fluorine atoms, more preferably a C₁₋₆ perfluoroalkylene group, and even more preferably a C₁₋₃ perfluoroalkylene group.

20 [0024] The C₁₋₆ perfluoroalkylene group may be straight or branched, and is preferably a straight or branched C₁₋₃ perfluoroalkylene group, more preferably a straight C₁₋₃ perfluoroalkyl group, and specifically -CF₂-, -CF₂CF₂-, or -CF₂CF₂CF₂-.

[0025] In the formulae, p is 0 or 1. In one embodiment, p is 0. In another embodiment, p is 1.

[0026] In the formulae, q is each independently at each occurrence 0 or 1. In one embodiment, q is 0. In another embodiment, q is 1.

25 [0027] In formulae (1) and (2), R^F is each independently at each occurrence a fluoropolyether group represented by the following formula. As for the structure referred to as R^F, the left side is bonded to a structure represented by R^{f1} in formula (1), and the left side is bonded to a structure represented by R^{f2}_p in formula (2).



30 wherein

R^{Fa} is each independently at each occurrence a hydrogen atom, a fluorine atom, or a chlorine atom;
a, b, c, d, e, and f are each independently an integer of 0 to 200; the sum of a, b, c, d, e, and f is 1 or more; and the occurrence order of each repeating unit enclosed in parentheses provided with a, b, c, d, e, or f is not limited in the formula.

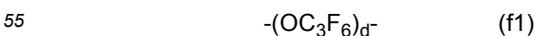
[0028] R^{Fa} is preferably a hydrogen atom or a fluorine atom, and more preferably a fluorine atom.

[0029] a, b, c, d, e, and f may be preferably each independently an integer of 0 to 100.

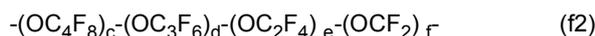
40 [0030] The sum of a, b, c, d, e, and f is preferably 5 or more and more preferably 10 or more, and may be, for example, 15 or more or 20 or more. The sum of a, b, c, d, e, and f is preferably 200 or less, more preferably 100 or less, even more preferably 60 or less, such as 50 or less or 30 or less.

[0031] These repeating units may be straight or branched, and are preferably straight. For example, -(OC₆F₁₂)- may be -(OCF₂CF₂CF₂CF₂CF₂CF₂)-, -(OCF(CF₃)CF₂CF₂CF₂CF₂)-, -(OCF₂CF(CF₃)CF₂CF₂CF₂)-, -(OCF₂CF₂CF(CF₃)CF₂CF₂)-, -(OCF₂CF₂CF₂CF(CF₃)CF₂)-, or the like, and is preferably -(OCF₂CF₂CF₂CF₂CF₂CF₂)-. -(OC₅F₁₀)- may be -(OCF₂CF₂CF₂CF₂CF₂)-, -(OCF(CF₃)CF₂CF₂CF₂CF₂)-, -(OCF₂CF(CF₃)CF₂CF₂CF₂)-, -(OCF₂CF₂CF(CF₃)CF₂CF₂)-, or the like, and is preferably -(OCF₂CF₂CF₂CF₂CF₂CF₂)-. -(OC₄F₈)- may be any of -(OCF₂CF₂CF₂CF₂CF₂)-, -(OCF(CF₃)CF₂CF₂CF₂)-, -(OCF₂CF(CF₃)CF₂CF₂CF₂)-, -(OCF₂CF₂CF(CF₃)CF₂CF₂)-, -(OC(CF₃)₂CF₂)-, -(OCF₂C(CF₃)₂)-, -(OCF(CF₃)CF(CF₃))-, -(OCF(C₂F₅)CF₂)-, and -(OCF₂CF(C₂F₅))-, and is preferably -(OCF₂CF₂CF₂CF₂CF₂)-. -(OC₃F₆)- (that is to say, in the formula, R^{Fa} is a fluorine atom) may be any of -(OCF₂CF₂CF₂CF₂)-, -(OCF(CF₃)CF₂CF₂)-, and -(OCF₂CF(CF₃))-, and is preferably -(OCF₂CF₂CF₂CF₂)-. Also, -(OC₂F₄)- may be any of -(OCF₂CF₂CF₂)- and -(OCF(CF₃))-, and is preferably -(OCF₂CF₂CF₂)-.

[0032] In one embodiment, R^F is each independently at each occurrence a group represented by formula (f1), (f2), or (f3) :



wherein d is an integer of 1 to 200;



wherein c and d are each independently an integer of 0 or more and 30 or less, e and f are each independently an integer of 1 or more and 200 or less, the sum of c, d, e, and f is 2 or more, and the occurrence order of each repeating unit enclosed in parentheses provided with a subscript c, d, e, or f is not limited in the formula;



wherein R⁶ is OCF₂ or OC₂F₄,

R⁷ is a group selected from OC₂F₄, OC₃F₆, OC₄F₈, OC₅F₁₀, and OC₆F₁₂, or is a combination of two or three groups independently selected from these groups, and g is an integer of 2 to 100;

-(OC₆F₁₂)_a-(OC₅F₁₀)_b-(OC₄F₈)_c-(OC₃F₆)_d-(OC₂F₄)_e-(OCF₂)_f (f4) wherein e is an integer of 1 or more and 200 or less, a, b, c, d, and f are each independently an integer of 0 or more and 200 or less, the sum of a, b, c, d, e, and f is at least 1, and the occurrence order of each repeating unit enclosed in parentheses provided with a, b, c, d, e, or f is not limited in the formula; and

-(OC₆F₁₂)_a-(OC₅F₁₀)_b-(OC₄F₈)_c-(OC₃F₆)_d-(OC₂F₄)_e-(OCF₂)_f (f5) wherein f is an integer of 1 or more and 200 or less, a, b, c, d, and e are each independently an integer of 0 or more and 200 or less, the sum of a, b, c, d, e, and f is at least 1, and the occurrence order of each repeating unit enclosed in parentheses provided with a, b, c, d, e, or f is not limited in the formula.

[0033] In formula (f1), d is preferably an integer of 5 to 200, more preferably 10 to 100, and even more preferably 15 to 50, such as 25 to 35. Formula (f1) is preferably a group represented by -(OCF₂CF₂CF₂)_d- or -(OCF(CF₃)CF₂)_d-, and is more preferably a group represented by -(OCF₂CF₂CF₂)_d-.

[0034] In formula (f2), e and f are each independently preferably an integer of 5 or more and 200 or less, and more preferably 10 to 200. The sum of c, d, e, and f is preferably 5 or more and more preferably 10 or more, and may be, for example, 15 or more or 20 or more. In one embodiment, formula (f2) is preferably a group represented by -(OCF₂CF₂CF₂CF₂)_c-(OCF₂CF₂CF₂)_d-(OCF₂CF₂)_e-(OCF₂)_f-. In another embodiment, formula (f2) may be a group represented by -(OC₂F₄)_e-(OCF₂)_f-.

[0035] In formula (f3), R⁶ is preferably OC₂F₄. In formula (f3), R⁷ is preferably a group selected from OC₂F₄, OC₃F₆, and OC₄F₈, or a combination of two or three groups independently selected from these groups, and is more preferably a group selected from OC₃F₆ and OC₄F₈. Examples of the combination of 2 or 3 groups independently selected from OC₂F₄, OC₃F₆, and OC₄F₈ include, but are not limited to, -OC₂F₄OC₃F₆-, -OC₂F₄OC₄F₈-, -OC₃F₆OC₂F₄-, -OC₃F₆OC₃F₆-, -OC₃F₆OC₄F₈-, -OC₄F₈OC₄F₈-, -OC₄F₈OC₃F₆-, -OC₄F₈OC₂F₄-, -OC₂F₄OC₂F₄OC₃F₆-, -OC₂F₄OC₂F₄OC₄F₈-, -OC₂F₄OC₃F₆OC₂F₄-, -OC₂F₄OC₃F₆OC₃F₆-, -OC₂F₄OC₄F₈OC₂F₄-, -OC₃F₆OC₂F₄OC₂F₄-, -OC₃F₆OC₂F₄OC₃F₆-, -OC₃F₆OC₃F₆OC₂F₄-, and -OC₄F₈OC₂F₄OC₂F₄-. In formula (f3), g is preferably an integer of 3 or more, and more preferably 5 or more. g is preferably an integer of 50 or less. In formula (f3), OC₂F₄, OC₃F₆, OC₄F₈, OC₅F₁₀, and OC₆F₁₂ may be either straight or branched, and are preferably straight. In this embodiment, formula (f3) is preferably -(OC₂F₄-OC₃F₆)_g- or -(OC₂F₄-OC₄F₈)_g-.

[0036] In formula (f4), e is preferably an integer of 1 or more and 100 or less, and more preferably 5 or more and 100 or less. The sum of a, b, c, d, e, and f is preferably 5 or more, and more preferably 10 or more, such as 10 or more and 100 or less.

[0037] In formula (f5), f is preferably an integer of 1 or more and 100 or less, and more preferably 5 or more and 100 or less. The sum of a, b, c, d, e, and f is preferably 5 or more, and more preferably 10 or more, such as 10 or more and 100 or less.

[0038] In one embodiment, R^F is a group represented by formula (f1).

[0039] In one embodiment, R^F is a group represented by formula (f2).

[0040] In one embodiment, R^F is a group represented by formula (f3).

[0041] In one embodiment, R^F is a group represented by formula (f4).

[0042] In one embodiment, R^F is a group represented by formula (f5).

[0043] The ratio of e to f in R^F (hereinafter, referred to as an "e/f ratio") is 0.1 to 10, preferably 0.2 to 5, more preferably 0.2 to 2, even more preferably 0.2 to 1.5, and further preferably 0.2 to 0.85. With an e/f ratio of 10 or less, the lubricity, friction durability, and chemical resistance (such as durability against artificial sweat) of a cured layer (such as a surface-treating layer) obtained from the compound are further increased. The smaller the e/f ratio is, the higher the lubricity and

the friction durability of a cured layer (such as a surface-treating layer). On the other hand, with an e/f ratio of 0.1 or more, the stability of the compound can be further increased. The larger the e/f ratio is, the higher the stability of the compound is.

[0044] In one embodiment, the e/f ratio is preferably 0.2 to 0.95, and more preferably 0.2 to 0.9.

[0045] In one embodiment, from the viewpoint of heat resistance, the e/f ratio is preferably 1.0 or more, and more preferably 1.0 to 2.0.

[0046] In one embodiment, the e/f ratio is 0.2 to 1.5, and preferably 0.5 to 1.1.

[0047] In one embodiment, the e/f ratio is 0.6 to 1.5.

[0048] In the fluoropolyether group-containing compound, the number average molecular weights of R^{F1} and R^{F2} moieties are not limited and are, for example, 500 to 30,000, preferably 1,500 to 30,000, more preferably 2,000 to 20,000, and even more preferably 2,000 to 10,000. Herein, the number average molecular weights of R^{F1} and R^{F2} are values measured by ¹⁹F-NMR.

[0049] In another embodiment, the number average molecular weights of R^{F1} and R^{F2} moieties may be 500 to 30,000, preferably 1,000 to 20,000, more preferably 2,000 to 15,000, and even more preferably 2,000 to 10,000, such as 3,000 to 6,500.

[0050] In another embodiment, the number average molecular weights of R^{F1} and R^{F2} moieties may be 4,000 to 30,000, preferably 5,000 to 10,000, and more preferably 6,000 to 10,000.

[0051] Herein, the group represented by R^{F1} or R^{F2} and the group represented by R^{Si} are bonded via -R^{X1}-O-R^{X2}-C(=O)-N. Here, in the compounds represented by formulae (1) and (2), the group represented by R^{F1} or R^{F2} is a group containing a fluoropolyether group that mainly provides water-repellency, surface slickness, and the like, and the group represented by R^{Si} is a silane moiety that provides the ability to bind to a substrate.

[0052] Having such a structure, the fluoropolyether group-containing compound of the present disclosure can contribute to the formation of a cured layer (for example, a surface-treating layer) having good friction durability (for example, skin friction durability, fabric friction durability, eraser friction durability, and steel wool friction durability), chemical resistance (for example, durability against a solvent, durability against artificial sweat, and durability against acid and alkali), water-repellency, oil-repellency, antifouling properties (for example, preventing grimes such as fingerprints from adhering), waterproof properties (preventing water from entering electronic components and the like), waterproof properties (preventing water from soaking electronic components and the like), surface slickness (or lubricity, e.g., removability of grimes such as fingerprints by wiping, and excellent tactile sensation), and the like. In particular, when the fluoropolyether group-containing compound of the present disclosure is used, the physical properties (for example, friction durability, chemical resistance, water-repellency, oil-repellency, antifouling properties, and lubricity) of a cured layer (for example, a surface-treating layer) formed can be improved. This is considered to be because the group represented by R^{X1}-O-R^{X2}-C(=O)-N is highly flexible, and thus the reaction between the terminal moiety of the group represented by R^{Si} and a substrate can proceed particularly favorably.

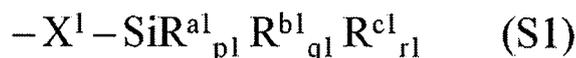
[0053] R^{X1} is each independently at each occurrence a C₁₋₆ alkylene group, and preferably a C₁₋₃ alkylene group, such as a methylene group.

[0054] R^{X2} is each independently at each occurrence a C₁₋₆ alkylene group (preferably a C₁₋₃ alkylene group, such as a methylene group) optionally substituted with a C₁₋₆ alkyl group or cyclic alkyl group optionally containing one or more nitrogen atoms, oxygen atoms, sulfur atoms, or silicon atoms, or with a perfluoroalkyl group. Here, when a nitrogen atom, an oxygen atom, a sulfur atom, or a silicon atom is contained in the C₁₋₆ alkyl group or the cyclic alkyl group, such an atom is contained in the molecular chain (i.e., between a carbon atom and a carbon atom) of the C₁₋₆ alkyl group or the cyclic alkyl group.

[0055] R^{X2} is each independently at each occurrence preferably a C₁₋₆ alkyl group, and more preferably a C₁₋₃ alkylene group, such as a methylene group.

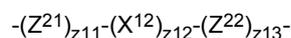
[0056] In one embodiment, R^{X1} is a C₁₋₆ alkylene group, and R^{X2} is a C₁₋₆ alkylene group, preferably R^{X1} is a C₁₋₃ alkylene group, and R^{X2} is a C₁₋₃ alkylene group, and, for example, R^{X1} and R^{X2} are both methylene groups.

[0057] R^{Si} is each independently at each occurrence represented by formula (S1) below.



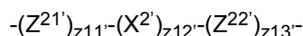
[0058] In formula (S1), X¹ is each independently at each occurrence a single bond, an oxygen atom, or a divalent organic group.

[0059] Examples of X¹ that is a divalent organic group include, but are not limited to, groups represented by:



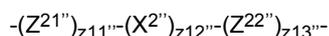
wherein Z²¹ and Z²² are a divalent organic group;
 X¹² is an oxygen atom;
 z₁₁ is 0 or 1; z₁₂ is 0 or 1; z₁₃ is 0 or 1; and at least one of z₁₁ and z₁₃ is 1.

- 5 [0060] In one embodiment, X¹ is a single bond.
 [0061] In one embodiment, X¹ is an oxygen atom.
 [0062] In one embodiment, X¹ is a divalent organic group.
 [0063] X¹ is preferably a C₁₋₆ alkylene group, -(CH₂)_{z₅}-O-(CH₂)_{z₆}- (wherein z₅ is an integer of 0 to 6, such as an integer of 1 to 6; z₆ is an integer of 0 to 6, such as an integer of 1 to 6; and the sum of z₅ and z₆ is 1 or more), or
 10 -(CH₂)_{z₇}-phenylene-(CH₂)_{z₈}- (wherein z₇ is an integer of 0 to 6, such as an integer of 1 to 6; z₈ is an integer of 0 to 6, such as an integer of 1 to 6; and preferably the sum of z₇ and z₈ is 1 or more). The C₁₋₆ alkylene group may be straight or branched, and is preferably straight. These groups may be substituted with one or more substituents selected from, for example, a fluorine atom, a C₁₋₆ alkyl group, a C₂₋₆ alkenyl group, and a C₂₋₆ alkynyl group, and are preferably unsubstituted.
 15 [0064] In a preferable embodiment, X¹ is a C₁₋₆ alkylene group or -(CH₂)_{z₇}-phenylene-(CH₂)_{z₈}-, preferably a C₁₋₆ alkylene group, and more preferably a C₁₋₃ alkylene group. Such a structure is advantageous in terms of increasing the friction durability and the chemical resistance of a cured layer (for example, a surface-treating layer) formed.
 [0065] In one embodiment, X¹ may be -CH₂CH₂CH₂-.
 [0066] R^{a1} is each independently at each occurrence -Z¹-SiR^{a1}_{p1}R^{b1}_{q1}R^{c1}_{r1}.
 20 [0067] Z^{1''} is each independently at each occurrence a single bond, an oxygen atom, or a divalent organic group.
 [0068] In one embodiment, Z^{1'} is a single bond.
 [0069] In one embodiment, Z^{1'} is an oxygen atom.
 [0070] Z^{1'} is preferably a divalent organic group.
 [0071] In a preferable embodiment, Z^{1'} does not form a siloxane bond with a Si atom to which Z^{1'} is bonded. That is
 25 to say, in formula (S1), (Si-Z^{1'}-Si) does not contain a siloxane bond.
 [0072] Examples of Z^{1'} that is a divalent organic group include, but are not limited to, groups represented by:



30 wherein Z^{21'} and Z^{22'} are a divalent organic group;
 X^{2'} is an oxygen atom;
 z_{11'} is 0 or 1; z_{12'} is 0 or 1; z_{13'} is 0 or 1, and at least one of z_{11'} and z_{13'} is 1.

- 35 [0073] Z^{1'} is preferably a C₁₋₆ alkylene group, -(CH₂)_{z₅'}-O-(CH₂)_{z₆'}- (wherein z₅' is an integer of 0 to 6, such as an integer of 1 to 6; z₆' is an integer of 0 to 6, such as an integer of 1 to 6; and the sum of z₅' and z₆' is 1 or more), or
 -(CH₂)_{z₇'}-phenylene-(CH₂)_{z₈'}- (wherein z₇' is an integer of 0 to 6, such as an integer of 1 to 6; z₈' is an integer of 0 to 6, such as an integer of 1 to 6; and preferably the sum of z₇' and z₈' is 1 or more). The C₁₋₆ alkylene group may be
 40 straight or branched, and is preferably straight. These groups may be substituted with one or more substituents selected from, for example, a fluorine atom, a C₁₋₆ alkyl group, a C₂₋₆ alkenyl group, and a C₂₋₆ alkynyl group, and are preferably unsubstituted.
 [0074] In a preferable embodiment, Z^{1'} is a C₁₋₆ alkylene group or -(CH₂)_{z₇'}-phenylene-(CH₂)_{z₈'}-, and preferably-phenylene-(CH₂)_{z₈'}-. When Z^{1'} is such a group, the light resistance or in particular the ultraviolet resistance of a cured film formed may be more increased. Preferably, z₇' is an integer of 0 to 6, and z₈' is an integer of 1 to 6.
 45 [0075] In another preferable embodiment, Z^{1'} is a C₁₋₆ alkylene group, and more preferably a C₁₋₃ alkylene group. Due to such a structure, the light resistance or in particular the ultraviolet resistance of a cured film formed may be more increased.
 [0076] In one embodiment, Z^{1'} may be -CH₂CH₂CH₂-. In another embodiment, Z^{1'} may be -CH₂CH₂-.
 [0077] R^{a1}' is each independently at each occurrence -Z^{1''}-SiR^{a1}'_{p1}R^{b1}'_{q1}R^{c1}'_{r1}.
 50 [0078] Z^{1''} is each independently at each occurrence a single bond, an oxygen atom, or a divalent organic group.
 [0079] In one embodiment, Z^{1''} is a single bond.
 [0080] In one embodiment, Z^{1''} is an oxygen atom.
 [0081] Z^{1''} is preferably a divalent organic group.
 [0082] In a preferable embodiment, Z^{1''} does not form a siloxane bond with a Si atom to which Z^{1''} is bonded. That is
 55 to say, in formula (S1), (Si-Z^{1''}-Si) does not contain a siloxane bond.
 [0083] Examples of Z^{1''} that is a divalent organic group include, but are not limited to, groups represented by:



wherein Z^{21''} and Z^{22''} are a divalent organic group;

X^{2''} is an oxygen atom;

z^{11''} is 0 or 1; z^{12''} is 0 or 1; z^{13''} is 0 or 1, and at least one of z^{11''} and z^{13''} is 1.

[0084] Z^{1''} is preferably a C₁₋₆ alkylene group, -(CH₂)_{z^{5''}}-O-(CH₂)_{z^{6''}}- (wherein z^{5''} is an integer of 0 to 6, such as an integer of 1 to 6; z^{6''} is an integer of 0 to 6, such as an integer of 1 to 6; and the sum of z^{5''} and z^{6''} is 1 or more), or -(CH₂)_{z^{7''}}-phenylene-(CH₂)_{z^{8''}}- (wherein z^{7''} is an integer of 0 to 6, such as an integer of 1 to 6; z^{8''} is an integer of 0 to 6, such as an integer of 1 to 6; and preferably the sum of z^{7''} and z^{8''} is 1 or more). The C₁₋₆ alkylene group may be straight or branched, and is preferably straight. These groups may be substituted with one or more substituents selected from, for example, a fluorine atom, a C₁₋₆ alkyl group, a C₂₋₆ alkenyl group, and a C₂₋₆ alkynyl group, and are preferably unsubstituted.

[0085] In a preferable embodiment, Z^{1''} is a C₁₋₆ alkylene group or -(CH₂)_{z^{7''}}-phenylene-(CH₂)_{z^{8''}}-, and preferably -phenylene-(CH₂)_{z^{8''}}-. When Z^{1''} is such a group, the light resistance or in particular the ultraviolet resistance of a cured film formed may be more increased. Preferably, z^{7''} is an integer of 0 to 6, and z^{8''} is an integer of 1 to 6.

[0086] In another preferable embodiment, Z^{1''} is a C₁₋₆ alkylene group, and more preferably a C₁₋₃ alkylene group. Due to such a structure, the light resistance or in particular the ultraviolet resistance of a cured film formed may be more increased.

[0087] In one embodiment, Z^{1''} may be -CH₂CH₂CH₂-. In another embodiment, Z^{1''} may be -CH₂CH₂-.

[0088] R^{a1'''} is each independently at each occurrence -Z^{1'''}-SiR^{b1'''}_{q^{1'''}}-R^{c1'''}_{r^{1'''}}-.

[0089] Z^{1'''} is each independently at each occurrence a single bond, an oxygen atom, or a divalent organic group.

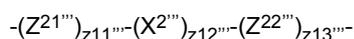
[0090] In one embodiment, Z^{1'''} is a single bond.

[0091] In one embodiment, Z^{1'''} is an oxygen atom.

[0092] Z^{1'''} is preferably a divalent organic group.

[0093] In a preferable embodiment, Z^{1'''} does not form a siloxane bond with a Si atom to which Z^{1'''} is bonded. That is to say, in formula (S1), (Si-Z^{1'''}-Si) does not contain a siloxane bond.

[0094] Examples of Z^{1'''} that is a divalent organic group include, but are not limited to, groups represented by:



wherein Z^{21'''} and Z^{22'''} are each a divalent organic group;

X^{2'''} is an oxygen atom;

z^{11'''} is 0 or 1; z^{12'''} is 0 or 1; z^{13'''} is 0 or 1, and at least one of z^{11'''} and z^{13'''} is 1.

[0095] Z^{1'''} is preferably a C₁₋₆ alkylene group, -(CH₂)_{z^{5'''}}-O-(CH₂)_{z^{6'''}}- (wherein z^{5'''} is an integer of 0 to 6, such as an integer of 1 to 6; z^{6'''} is an integer of 0 to 6, such as an integer of 1 to 6; and the sum of z^{5'''} and z^{6'''} is 1 or more), or -(CH₂)_{z^{7'''}}-phenylene-(CH₂)_{z^{8'''}}- (wherein z^{7'''} is an integer of 0 to 6, such as an integer of 1 to 6; z^{8'''} is an integer of 0 to 6, such as an integer of 1 to 6; and preferably the sum of z^{7'''} and z^{8'''} is 1 or more). The C₁₋₆ alkylene group may be straight or branched, and is preferably straight. These groups may be substituted with one or more substituents selected from, for example, a fluorine atom, a C₁₋₆ alkyl group, a C₂₋₆ alkenyl group, and a C₂₋₆ alkynyl group, and are preferably unsubstituted.

[0096] In a preferable embodiment, Z^{1'''} is a C₁₋₆ alkylene group or -(CH₂)_{z^{7'''}}-phenylene-(CH₂)_{z^{8'''}}-, and preferably -phenylene-(CH₂)_{z^{8'''}}-. When Z^{1'''} is such a group, the light resistance or in particular the ultraviolet resistance of a cured film formed may be more increased. Preferably, z^{7'''} is an integer of 0 to 6, and z^{8'''} is an integer of 1 to 6.

[0097] In another preferable embodiment, Z^{1'''} is a C₁₋₆ alkylene group, and more preferably a C₁₋₃ alkylene group. Due to such a structure, the light resistance or in particular the ultraviolet resistance of a cured film formed may be more increased.

[0098] In one embodiment, Z^{1'''} may be -CH₂CH₂CH₂-. In another embodiment, Z^{1'''} may be -CH₂CH₂-.

[0099] R^{b1'''} is each independently at each occurrence a hydroxyl group or a hydrolyzable group. R^{b1'''} is preferably each independently at each occurrence a hydrolyzable group.

[0100] R^{b1'''} is preferably each independently at each occurrence -OR^h, -OCOR^h, -O-N=CR^h₂, -NR^h₂, -NHR^h, or halogen (in these formulae, R^h represents a substituted or unsubstituted C₁₋₄ alkyl group), and more preferably -OR^h (i.e., an alkoxy group). Examples of R^h include unsubstituted alkyl groups such as a methyl group, an ethyl group, a propyl group, an isopropyl group, a n-butyl group, and an isobutyl group; and substituted alkyl groups such as a chloromethyl group. Among such groups, an alkyl group or in particular an unsubstituted alkyl group is preferable, and a methyl group or an ethyl group is more preferable. In one embodiment, R^h is a methyl group, and in another embodiment, R^h is an

ethyl group.

[0101] $R^{c1''}$ is each independently at each occurrence a hydrogen atom or a monovalent organic group. Such a monovalent organic group does not include the above hydrolyzable group.

[0102] In $R^{c1''}$, the monovalent organic group is preferably a C_{1-20} alkyl group, more preferably a C_{1-6} alkyl group, and even more preferably a methyl group.

[0103] $q^{1''}$ is each independently at each occurrence an integer of 0 to 3, and $r^{1''}$ is each independently at each occurrence 0 to 3. The sum of $q^{1''}$ and $r^{1''}$ is 3 in the $(SiR^{b1''}_{q^{1''}}R^{c1''}_{r^{1''}})$ unit.

[0104] Preferably $q^{1''}$ is an integer of 1 to 3, $r^{1''}$ is an integer of 0 to 2, more preferably $q^{1''}$ is 2 or 3, and $r^{1''}$ is 0 or 1, and particularly preferably $q^{1''}$ is 3.

[0105] $R^{b1''}$ is each independently at each occurrence a hydroxyl group or a hydrolyzable group. $R^{b1''}$ is preferably each independently at each occurrence a hydrolyzable group.

[0106] $R^{b1''}$ is preferably each independently at each occurrence $-OR^h$, $-OCOR^h$, $-O-N=CR^h_2$, $-NR^h_2$, $-NHR^h$, or halogen (in these formulae, R^h represents a substituted or unsubstituted C_{1-4} alkyl group), and more preferably $-OR^h$ (i.e., an alkoxy group). Examples of R^h include unsubstituted alkyl groups such as a methyl group, an ethyl group, a propyl group, an isopropyl group, a n-butyl group, and an isobutyl group; and substituted alkyl groups such as a chloromethyl group. Among such groups, an alkyl group or in particular an unsubstituted alkyl group is preferable, and a methyl group or an ethyl group is more preferable. In one embodiment, R^h is a methyl group, and in another embodiment, R^h is an ethyl group.

[0107] $R^{c1''}$ is each independently at each occurrence a hydrogen atom or a monovalent organic group. Such a monovalent organic group does not include the above hydrolyzable group.

[0108] In $R^{c1''}$, the monovalent organic group is preferably a C_{1-20} alkyl group, more preferably a C_{1-6} alkyl group, and even more preferably a methyl group.

[0109] $p^{1''}$ is each independently at each occurrence an integer of 0 to 3, $q^{1''}$ is each independently at each occurrence an integer of 0 to 3, and $r^{1''}$ is each independently at each occurrence an integer of 0 to 3. The sum of $p^{1''}$, $q^{1''}$, and $r^{1''}$ is 3 in the $(SiR^{a1''}_{p^{1''}}R^{b1''}_{q^{1''}}R^{c1''}_{r^{1''}})$ unit.

[0110] In one embodiment, $p^{1''}$ is 0.

[0111] In one embodiment, $p^{1''}$ may be each independently an integer of 1 to 3, an integer of 2 to 3, or 3 for each $(SiR^{a1''}_{p^{1''}}R^{b1''}_{q^{1''}}R^{c1''}_{r^{1''}})$ unit. In a preferable embodiment, $p^{1''}$ is 3.

[0112] In one embodiment, $q^{1''}$ is each independently an integer of 1 to 3, preferably an integer of 2 to 3, and more preferably 3 for each $(SiR^{a1''}_{p^{1''}}R^{b1''}_{q^{1''}}R^{c1''}_{r^{1''}})$ unit.

[0113] In one embodiment, $p^{1''}$ is 0, and $q^{1''}$ is each independently an integer of 1 to 3, preferably an integer of 2 to 3, and more preferably 3 for each $(SiR^{a1''}_{p^{1''}}R^{b1''}_{q^{1''}}R^{c1''}_{r^{1''}})$ unit.

[0114] $R^{b1'}$ is each independently at each occurrence a hydroxyl group or a hydrolyzable group. $R^{b1'}$ is preferably each independently at each occurrence a hydrolyzable group.

[0115] $R^{b1'}$ is preferably each independently at each occurrence $-OR^h$, $-OCOR^h$, $-O-N=CR^h_2$, $-NR^h_2$, $-NHR^h$, or halogen (in these formulae, R^h represents a substituted or unsubstituted C_{1-4} alkyl group), and more preferably $-OR^h$ (i.e., an alkoxy group). Examples of R^h include unsubstituted alkyl groups such as a methyl group, an ethyl group, a propyl group, an isopropyl group, a n-butyl group, and an isobutyl group; and substituted alkyl groups such as a chloromethyl group. Among such groups, an alkyl group or in particular an unsubstituted alkyl group is preferable, and a methyl group or an ethyl group is more preferable. In one embodiment, R^h is a methyl group, and in another embodiment, R^h is an ethyl group.

[0116] $R^{c1'}$ is each independently at each occurrence a hydrogen atom or a monovalent organic group. Such a monovalent organic group does not include the above hydrolyzable group.

[0117] In $R^{c1'}$, the monovalent organic group is preferably a C_{1-20} alkyl group, more preferably a C_{1-6} alkyl group, and even more preferably a methyl group.

[0118] $p^{1'}$ is each independently at each occurrence an integer of 0 to 3, $q^{1'}$ is each independently at each occurrence an integer of 0 to 3, and $r^{1'}$ is each independently at each occurrence an integer of 0 to 3. The sum of $p^{1'}$, $q^{1'}$, and $r^{1'}$ is 3 in the $(SiR^{a1'}_{p^{1'}}R^{b1'}_{q^{1'}}R^{c1'}_{r^{1'}})$ unit.

[0119] In one embodiment, $p^{1'}$ is 0.

[0120] In one embodiment, $p^{1'}$ may be each independently an integer of 1 to 3, an integer of 2 to 3, or 3 for each $(SiR^{a1'}_{p^{1'}}R^{b1'}_{q^{1'}}R^{c1'}_{r^{1'}})$ unit. In a preferable embodiment, $p^{1'}$ is 3.

[0121] In one embodiment, $q^{1'}$ is each independently an integer of 1 to 3, preferably an integer of 2 to 3, and more preferably 3 for each $(SiR^{a1'}_{p^{1'}}R^{b1'}_{q^{1'}}R^{c1'}_{r^{1'}})$ unit.

[0122] In one embodiment, $p^{1'}$ is 0, and $q^{1'}$ is each independently an integer of 1 to 3, preferably an integer of 2 to 3, and more preferably 3 for each $(SiR^{a1'}_{p^{1'}}R^{b1'}_{q^{1'}}R^{c1'}_{r^{1'}})$ unit.

[0123] R^{b1} is each independently at each occurrence a hydroxyl group or a hydrolyzable group. R^{b1} is preferably each independently at each occurrence a hydrolyzable group.

[0124] R^{c1} is each independently at each occurrence a hydrogen atom or a monovalent organic group. Such a monovalent organic group does not include the above hydrolyzable group.

[0125] In R^{c1} , the monovalent organic group is preferably a C_{1-20} alkyl group, more preferably a C_{1-6} alkyl group, and

even more preferably a methyl group.

[0126] p₁ is each independently at each occurrence an integer of 0 to 3, q₁ is each independently at each occurrence an integer of 0 to 3, and r₁ is each independently at each occurrence an integer of 0 to 3. The sum of p₁, q₁, and r₁ is 3 in the (SiR^{a1}_{p1}R^{b1}_{q1}R^{c1}_{r1}) unit.

[0127] In one embodiment, p₁ is 0.

[0128] In one embodiment, p₁ may be each independently an integer of 1 to 3, an integer of 2 to 3, or 3 for each (SiR^{a1}_{p1}R^{b1}_{q1}R^{c1}_{r1}) unit. In a preferable embodiment, p₁ is 3.

[0129] In one embodiment, q₁ is each independently an integer of 1 to 3, preferably an integer of 2 to 3, and more preferably 3 for each (SiR^{a1}_{p1}R^{b1}_{q1}R^{c1}_{r1}) unit.

[0130] In one embodiment, p₁ is 0, and q₁ is each independently an integer of 1 to 3, preferably an integer of 2 to 3, and more preferably 3 for each (SiR^{a1}_{p1}R^{b1}_{q1}R^{c1}_{r1}) unit.

[0131] At least one R^{b1}, R^{b1'}, R^{b1''}, or R^{b1'''} is present for each group represented by R^{Si}. That is to say, in formula (1) or (2), each group represented by R^{Si} bonded to the N atom has at least one Si atom to which a hydroxyl group or a hydrolyzable group binds.

[0132] In other words, the group represented by R^{Si} has at least one of:

a group represented by -X¹-SiR^{a1}_{p1}R^{b1}_{q1}R^{c1}_{r1} (wherein q₁ is an integer of 1 to 3, preferably q₁ is 2 or 3, and more preferably q₁ is 3, and the sum of p₁, q₁, and r₁ is 3);

a group represented by -Z^{1'}-SiR^{a1'}_{p1'}R^{b1'}_{q1'}R^{c1'}_{r1'} (wherein q_{1'} is an integer of 1 to 3, preferably q_{1'} is 2 or 3, and more preferably q_{1'} is 3, and the sum of p_{1'}, q_{1'}, and r_{1'} is 3); or

a group represented by -Z^{1''}-SiR^{a1''}_{p1''}R^{b1''}_{q1''}R^{c1''}_{r1''} (wherein q_{1''} is an integer of 1 to 3, preferably q_{1''} is 2 or 3, and more preferably q_{1''} is 3, and the sum of p_{1''}, q_{1''}, and r_{1''} is 3); and

a group represented by -Z^{1'''}-SiR^{b1'''}_{q1'''}R^{c1'''}_{r1'''} (wherein q_{1'''} is an integer of 1 to 3, preferably q_{1'''} is 2 or 3, and more preferably q_{1'''} is 3, and the sum of q_{1'''} and r_{1'''} is 3).

[0133] The Si atom to which a hydroxyl group or a hydrolyzable group binds preferably is present at the terminal moiety of the group represented by R^{Si}. In other words, preferably, the Si atom to which a hydroxyl group or a hydrolyzable group binds is present at the terminal moieties of formulae (1) and (2).

[0134] The group represented by R^{Si} preferably has at least one of:

a group represented by -X¹-SiR^{b1}_{q1}R^{c1}_{r1} (wherein q₁ is an integer of 1 to 3, preferably q₁ is 2 or 3, and more preferably q₁ is 3, and the sum of q₁ and r₁ is 3);

a group represented by -Z^{1'}-SiR^{b1'}_{q1'}R^{c1'}_{r1'} (wherein q_{1'} is an integer of 1 to 3, preferably q_{1'} is 2 or 3, and more preferably q_{1'} is 3, and provided that the sum of q_{1'} and r_{1'} is 3);

a group represented by -Z^{1''}-SiR^{b1''}_{q1''}R^{c1''}_{r1''} (wherein q_{1''} is an integer of 1 to 3, preferably q_{1''} is 2 or 3, and more preferably q_{1''} is 3, provided that the sum of q_{1''} and r_{1''} is 3); and

a group represented by -Z^{1'''}-SiR^{b1'''}_{q1'''}R^{c1'''}_{r1'''} (wherein q_{1'''} is an integer of 1 to 3, preferably q_{1'''} is 2 or 3, and more preferably q_{1'''} is 3, and the sum of q_{1'''} and r_{1'''} is 3).

[0135] R^{Si} is preferably -X¹-SiR^{b1}₂R^{c1}₃ or -X¹-SiR^{b1}₃, and more preferably -X¹-SiR^{b1}₃.

[0136] In one embodiment, when p₁ is an integer of 1 to 3 in R^{Si}, R^{a1} is preferably -Z^{1'}-SiR^{b1'}₂R^{c1'}₃ or -Z^{1'}-SiR^{b1'}₃, and more preferably -Z^{1'}-SiR^{b1'}₃. In this embodiment, p₁ is preferably 2 or 3, and more preferably 3.

[0137] In one embodiment, when p_{1'} is an integer of 1 to 3 in R^{Si}, R^{a1'} is preferably -Z^{1''}-SiR^{b1''}₂R^{c1''}₃ or -Z^{1''}-SiR^{b1''}₃, and more preferably -Z^{1''}-SiR^{b1''}₃. In this embodiment, p_{1'} is preferably 2 or 3, and more preferably 3.

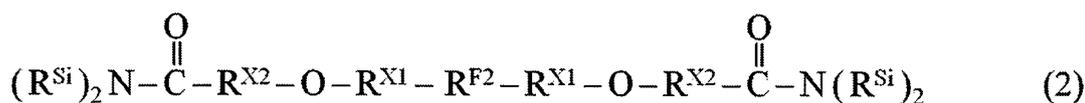
[0138] In one embodiment, when p_{1''} is an integer of 1 to 3 in R^{Si}, R^{a1''} is preferably -Z^{1'''}-SiR^{b1'''}₂R^{c1'''}₃ or -Z^{1'''}-SiR^{b1'''}₃, and more preferably -Z^{1'''}-SiR^{b1'''}₃. In this embodiment, p_{1''} is preferably 2 or 3, and more preferably 3.

[0139] In one embodiment, the fluoropolyether group-containing compound of the present disclosure is a compound represented by formula (1).

[0140] In one embodiment, the fluoropolyether group-containing compound of the present disclosure is a compound represented by formula (2).

[0141] In one embodiment, the fluoropolyether group-containing compound of the present disclosure is represented by formula (1) or (2) below:





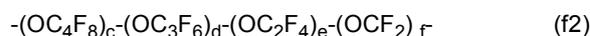
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wherein

R^{F1} is R^{f1}-R^F-O_q-;R^{F2} is -R^{f2}_p-R^F-O_q-;10 R^{f1} is a C₁₋₁₆ alkyl group optionally substituted with one or more fluorine atoms;R^{f2} is a C₁₋₆ alkylene group optionally substituted with one or more fluorine atoms;R^F is each independently at each occurrence a group represented by formula (f1), (f2), (f3), (f4), or (f5) below:

15

in formula (f1), d is an integer of 1 to 200;



20 in formula (f2), c and d are each independently an integer of 0 or more and 30 or less, e and f are each independently an integer of 1 or more and 200 or less,

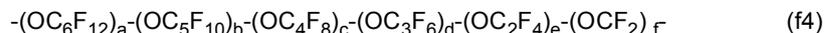
the sum of c, d, e, and f is 2 or more, and

the occurrence order of each repeating unit enclosed in parentheses provided with a subscript c, d, e, or f is not limited in the formula;

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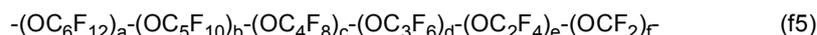
in formula (f3), R⁶ is OCF₂ or OC₂F₄,R⁷ is a group selected from OC₂F₄, OC₃F₆, OC₄F₈, OC₅F₁₀, and OC₆F₁₂, or is a combination of two or three groups independently selected from these groups, and g is an integer of 2 to 100;

30



35

in formula (f4), e is an integer of 1 or more and 200 or less, a, b, c, d, and f are each independently an integer of 0 or more and 200 or less, the sum of a, b, c, d, e, and f is at least 1, and the occurrence order of each repeating unit enclosed in parentheses provided with a, b, c, d, e, or f is not limited in the formula; and



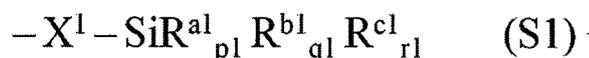
40 in formula (f5), f is an integer of 1 or more and 200 or less, a, b, c, d, and e are each independently an integer of 0 or more and 200 or less, the sum of a, b, c, d, e, and f is at least 1, and the occurrence order of each repeating unit enclosed in parentheses provided with a, b, c, d, e, or f is not limited in the formula;

p is 0 or 1;

q is 0 or 1;

45 R^{X1} is each independently at each occurrence a C₁₋₆ alkylene group, and preferably a C₁₋₃ alkylene group, such as a methylene group;R^{X2} is each independently at each occurrence a C₁₋₆ alkylene group, and preferably a C₁₋₃ alkylene group, such as a methylene group;R^{Si} is each independently at each occurrence represented by formula (S1) below:

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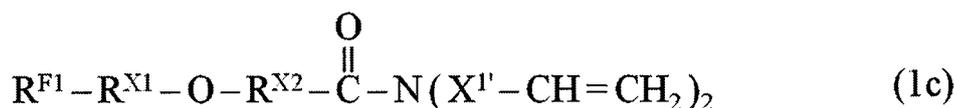
55 X¹ is each independently at each occurrence a C₁₋₆ alkylene group or -(CH₂)_{z7}-phenylene-(CH₂)_{z8}-, preferably a C₁₋₆ alkylene group, and more preferably a C₁₋₃ alkylene group;z₇ is an integer of 0 to 6, and z₈ is an integer of 1 to 6;R^{b1} is each independently at each occurrence a hydroxyl group or a hydrolyzable group; and

p1 and r1 are 0, and q1 is 3.

[0142] The compound represented by formula (1) or formula (2) can be produced by combining known methods.

[0143] As one embodiment, a method suitable for producing the fluoropolyether group-containing compound of the present disclosure represented by formula (1) will now be described below.

[0144] The fluoropolyether group-containing compound of the present disclosure can be produced by, for example, a method comprising reacting a compound represented by formula (1c) with HSiM_3 (wherein M is each independently a halogen atom (i.e., I, Br, Cl, or F) or a C_{1-6} alkoxy group, preferably a halogen atom, and more preferably Cl) and, as desired, a compound represented by $\text{R}^{\text{b}1}\text{L}'$ ($\text{R}^{\text{b}1}$ has the same definition as above, and L' represents a group capable of binding to $\text{R}^{\text{b}1}$) and/or a compound represented by $\text{R}^{\text{c}1}\text{L}''$ ($\text{R}^{\text{c}1}$ has the same definition as above, and L'' represents a group capable of binding to $\text{R}^{\text{c}1}$).



[0145] In formulae (1c), $\text{R}^{\text{F}1}$, $\text{R}^{\text{X}1}$, and $\text{R}^{\text{X}2}$ have the same definitions as those of $\text{R}^{\text{F}1}$, $\text{R}^{\text{X}1}$, and $\text{R}^{\text{X}2}$ in formula (1), respectively. $\text{X}^{1'}$ represents a structure having two fewer carbon atoms than X^1 of formula (1). $-\text{X}^{1'}-\text{CH}_2\text{CH}_2-$ derived from the structure represented by $-\text{X}^1-\text{CH}=\text{CH}_2$ corresponds to X^1 in formula (1).

[0146] The above step is preferably carried out in a suitable solvent in the presence of a suitable catalyst.

[0147] Examples of the suitable catalyst include, but are not limited to, Pt, Pd, and Rh. Such a catalyst may be in any form, e.g., in the form of a complex.

[0148] The suitable solvent is not limited as long as it does not adversely affect the reaction, and examples include 1,3-bis(trifluoromethyl)benzene, perfluorobutyl ethyl ether, perfluorohexyl methyl ether, perfluorohexane, and hexafluorobenzene.

[0149] The reaction temperature in the reaction is not limited, and is usually 0 to 100°C and preferably 50 to 80°C; the reaction time is not limited, and is usually 60 to 600 minutes and preferably 120 to 300 minutes; and the reaction pressure is not limited, and is -0.2 to 1 MPa (gauge pressure) and conveniently is atmospheric pressure.

[0150] The compound represented by formula (1c) can be produced by, but is not limited to, for example, introducing a group having a double bond into the terminal moiety of the compound represented by formula (1b). Specifically, the compound can be obtained by reacting a compound represented by formula (1b) below with an amine compound having a double bond at the terminal moiety (such as allylamine or diallylamine). R^{X} is a hydrogen atom, a hydroxyl group, an alkoxy group having 1 to 10 carbon atoms, a phenol group, a sulfonyl group, halogen, or the like, and is specifically halogen.



[0151] The above step is preferably carried out in a suitable solvent in the presence of a suitable base.

[0152] The suitable base is not particularly limited, and examples include lithium hydroxide, sodium hydroxide, potassium hydroxide, sodium carbonate, potassium carbonate, sodium hydrogencarbonate, potassium hydrogencarbonate, and tertiary amines (triethylamine, pyridine, diisopropylethylamine, and 2,6-lutidine). Such a base may be in any form.

[0153] The suitable solvent is not limited as long as it does not adversely affect the reaction, and examples include 1,3-bis(trifluoromethyl)benzene, perfluorobutyl ethyl ether, perfluorohexyl methyl ether, perfluorohexane, and hexafluorobenzene.

[0154] The reaction temperature in the reaction is not limited, and is usually 0 to 100°C and preferably 40 to 80°C; the reaction time is not limited, and is usually 60 to 600 minutes and preferably 120 to 240 minutes; and the reaction pressure is not limited, and is -0.2 to 1 MPa (gauge pressure) and conveniently is atmospheric pressure.

[0155] The compound represented by formula (1b) can be obtained by, but is not limited to, for example, introducing $\text{Hal}-\text{R}^{\text{X}2}-\text{C}(=\text{O})-\text{R}^{\text{X}}$ into the OH group at the terminal of a compound represented by formula (1a). Here, Hal is a halogen atom, such as a Br atom.



[0156] The above step is preferably carried out in a suitable solvent in the presence of a suitable base.

[0157] The suitable base is not particularly limited, and examples include lithium hydroxide, sodium hydroxide, potassium hydroxide, sodium carbonate, potassium carbonate, sodium hydrogencarbonate, potassium hydrogencarbonate, and tertiary amines (triethylamine, pyridine, diisopropylethylamine, and 2,6-lutidine). Such a base may be in any form.

[0158] The suitable solvent is not limited as long as it does not adversely affect the reaction, and examples include 1,3-bis(trifluoromethyl)benzene, perfluorobutyl ethyl ether, perfluorohexyl methyl ether, perfluorohexane, and hexafluorobenzene.

[0159] The reaction temperature in the reaction is not limited, and is usually 0 to 100°C and preferably 50 to 100°C; the reaction time is not limited, and is usually 60 to 600 minutes and preferably 80 to 240 minutes; and the reaction pressure is not limited, and is -0.2 to 1 MPa (gauge pressure) and conveniently is atmospheric pressure.

[0160] In another embodiment, the compound represented by formula (1c) can be synthesized by, but is not limited to, a method comprising reacting a compound represented by formula (1a) with a compound represented by Hal-R^{X2}-C(O)N(X¹-CH=CH₂)₂. Here, Hal, R^{X2}, X¹, R^{F1}, and R^{X1} have the same meanings as described above.



[0161] The above step is preferably carried out in a suitable solvent in the presence of a suitable base.

[0162] The suitable base is not particularly limited, and examples include lithium hydroxide, sodium hydroxide, potassium hydroxide, sodium carbonate, potassium carbonate, sodium hydrogencarbonate, potassium hydrogencarbonate, and tertiary amines (triethylamine, pyridine, diisopropylethylamine, and 2,6-lutidine). Such a base may be in any form.

[0163] The suitable solvent is not limited as long as it does not adversely affect the reaction, and examples include 1,3-bis(trifluoromethyl)benzene, perfluorobutyl ethyl ether, perfluorohexyl methyl ether, perfluorohexane, and hexafluorobenzene.

[0164] The reaction temperature in the reaction is not limited, and is usually 0 to 100°C and preferably 50 to 100°C; the reaction time is not limited, and is usually 60 to 600 minutes and preferably 100 to 300 minutes; and the reaction pressure is not limited, and is -0.2 to 1 MPa (gauge pressure) and conveniently is atmospheric pressure.

[0165] The reaction conditions when producing the fluoropolyether group-containing silane compound of the present disclosure can be suitably regulated to a preferable range by those skilled in the art.

[0166] Below, the composition (for example, a surface-treating agent) of the present disclosure will now be described.

[0167] The composition (for example, a surface-treating agent) of the present disclosure contains at least one fluoropolyether group-containing compound represented by formula (1) or formula (2).

[0168] In one embodiment, the composition (for example, a surface-treating agent) of the present disclosure may contain the fluoropolyether group-containing compounds of formula (1) and formula (2).

[0169] In one embodiment, the lower limit of the ratio (molar ratio) of the fluoropolyether group-containing compound of formula (2) to the total of the fluoropolyether group-containing compounds of formulae (1) and (2) contained in the composition (for example, a surface-treating agent) of the present disclosure may be preferably 0.001, more preferably 0.002, even more preferably 0.005, yet more preferably 0.01, particularly preferably 0.02, and especially 0.05. The upper limit of the ratio (molar ratio) of the fluoropolyether group-containing compound of formula (2) to the total of the fluoropolyether group-containing compounds of formulae (1) and (2) may be preferably 0.35, more preferably 0.30, even more preferably 0.20, and yet more preferably 0.15 or 0.10. The ratio (molar ratio) of the fluoropolyether group-containing compound of formula (2) to the total of the fluoropolyether group-containing compounds of formulae (1) and (2) is preferably 0.001 or more and 0.30 or less, more preferably 0.001 or more and 0.20 or less, even more preferably 0.002 or more and 0.20 or less, yet more preferably 0.005 or more and 0.20 or less, and particularly preferably 0.01 or more and 0.20 or less, such as 0.02 or more and 0.15 or less, or 0.05 or more and 0.15 or less. By containing the fluoropolyether group-containing compound of formula (2) in the above range, the composition of the present disclosure can contribute to the formation of a cured layer having good friction durability.

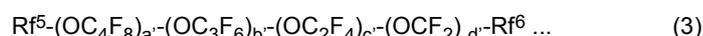
[0170] The composition (for example, a surface-treating agent) of the present disclosure is capable of imparting water-repellency, oil-repellency, antifouling properties, waterproof properties, surface slickness, and friction durability to a substrate, and can be suitably used as, but is not limited to, an antifouling coating agent or a water-proof coating agent.

[0171] The composition (for example, a surface-treating agent) of the present disclosure may further contain a solvent, a (non-reactive) fluoropolyether compound that can be understood as a fluorine-containing oil or preferably a perfluoro(poly)ether compound (hereinafter, collectively referred to as a "fluorine-containing oil"), a (non-reactive) silicone compound that can be understood as a silicone oil (hereinafter, referred to as a "silicone oil"), a catalyst, a surfactant, a polymerization inhibitor, a sensitizer, and the like.

[0172] Examples of the solvent include aliphatic hydrocarbons such as hexane, cyclohexane, heptane, octane, nonane, decane, undecane, dodecane, and mineral spirits; aromatic hydrocarbons such as benzene, toluene, xylene, naphthalene, and solvent naphtha; esters such as methyl acetate, ethyl acetate, propyl acetate, n-butyl acetate, isopropyl acetate,

isobutyl acetate, cellosolve acetate, propylene glycol methyl ether acetate, carbitol acetate, diethyl oxalate, ethyl pyruvate, ethyl 2-hydroxybutyrate, ethyl acetoacetate, amyl acetate, methyl lactate, ethyl lactate, methyl 3-methoxypropionate, ethyl 3-methoxypropionate, methyl 2-hydroxyisobutyrate, and ethyl 2-hydroxyisobutyrate; ketones such as acetone, methyl ethyl ketone, methyl isobutyl ketone, 2-hexanone, cyclohexanone, methyl amino ketone, and 2-heptanone; glycol ethers such as ethyl cellosolve, methyl cellosolve, methyl cellosolve acetate, ethyl cellosolve acetate, propylene glycol monomethyl ether, propylene glycol monoethyl ether, propylene glycol monobutyl ether, propylene glycol monomethyl ether acetate, propylene glycol monoethyl ether acetate, propylene glycol monobutyl ether acetate, dipropylene glycol dimethyl ether, and ethylene glycol monoalkyl ether; alcohols such as methanol, ethanol, iso-propanol, n-butanol, isobutanol, tert-butanol, sec-butanol, 3-pentanol, octyl alcohol, 3-methyl-3-methoxybutanol, and tert-amyl alcohol; glycols such as ethylene glycol and propylene glycol; cyclic ethers such as tetrahydrofuran, tetrahydropyran, and dioxane; amides such as N,N-dimethylformamide and N,N-dimethylacetamide; ether alcohols such as methyl cellosolve, cellosolve, isopropyl cellosolve, butyl cellosolve, and diethylene glycol monomethyl ether; diethylene glycol monoethyl ether acetate; and fluorine-containing solvents such as 1,1,2-trichloro-1,2,2-trifluoroethane, 1,2-dichloro-1,1,2,2-tetrafluoroethane, dimethyl sulfoxide, 1,1-dichloro-1,2,2,3,3-pentafluoropropane (HCFC 225), Zeorora H, HFE 7100, HFE 7200, and HFE 7300. Alternatively, the solvent may be a mixed solvent of two or more of such solvents.

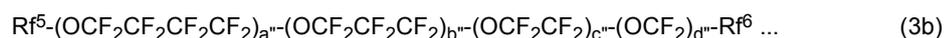
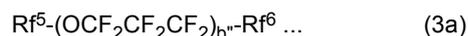
[0173] The fluorine-containing oil is not limited, and examples include compounds (perfluoro(poly)ether compounds) represented by general formula (3) below:



wherein Rf^5 represents a C_{1-16} alkyl group optionally substituted with one or more fluorine atoms (preferably a C_{1-16} perfluoroalkyl group), Rf^6 represents a C_{1-16} alkyl group optionally substituted with one or more fluorine atoms (preferably a C_{1-16} perfluoroalkyl group), a fluorine atom, or a hydrogen atom, and Rf^5 and Rf^6 are more preferably each independently a C_{1-3} perfluoroalkyl group.

[0174] a' , b' , c' , and d' respectively represent the numbers of 4 repeating units of perfluoro(poly)ether constituting the main backbone of the polymer and are mutually independently an integer of 0 or more and 300 or less, and the sum of a' , b' , c' , and d' is at least 1, preferably 1 to 300, and more preferably 20 to 300. The occurrence order of each repeating unit enclosed in parentheses provided with a subscript a' , b' , c' , or d' is not limited in the formula. Among these repeating units, $-(\text{OC}_4\text{F}_8)-$ may be any of $-(\text{OCF}_2\text{CF}_2\text{CF}_2\text{CF}_2)-$, $-(\text{OCF}(\text{CF}_3)\text{CF}_2\text{CF}_2)-$, $-(\text{OCF}_2\text{CF}(\text{CF}_3)\text{CF}_2)-$, $-(\text{OCF}_2\text{CF}_2\text{CF}(\text{CF}_3))-$, $-(\text{OC}(\text{CF}_3)_2\text{CF}_2)-$, $-(\text{OCF}_2\text{C}(\text{CF}_3)_2)-$, $-(\text{OCF}(\text{CF}_3)\text{CF}(\text{CF}_3))-$, $-(\text{OCF}(\text{C}_2\text{F}_5)\text{CF}_2)-$, and $(\text{OCF}_2\text{CF}(\text{C}_2\text{F}_5))-$, and preferably $-(\text{OCF}_2\text{CF}_2\text{CF}_2\text{CF}_2)-$. $-(\text{OC}_3\text{F}_6)-$ may be any of $-(\text{OCF}_2\text{CF}_2\text{CF}_2)-$, $-(\text{OCF}(\text{CF}_3)\text{CF}_2)-$, and $(\text{OCF}_2\text{CF}(\text{CF}_3))-$, and is preferably $-(\text{OCF}_2\text{CF}_2\text{CF}_2)-$. $-(\text{OC}_2\text{F}_4)-$ may be any of $-(\text{OCF}_2\text{CF}_2)-$ and $(\text{OCF}(\text{CF}_3))-$, and is preferably $-(\text{OCF}_2\text{CF}_2)-$.

[0175] Examples of the perfluoro(poly)ether compound represented by general formula (3) include compounds represented by any of general formulae (3a) and (3b) below (which may be used singly or as a mixture of two or more):



[0176] In these formulae, Rf^5 and Rf^6 are as described above; in formula (3a), b is an integer of 1 or more and 100 or less; and in formula (3b), a and b are each independently an integer of 0 or more and 30 or less, and c and d are each independently an integer of 1 or more and 300 or less. The occurrence order of each repeating unit enclosed in parentheses provided with a subscript a , b , c , or d is not limited in the formulae.

[0177] From another viewpoint, the fluorine-containing oil may be a compound represented by general formula Rf^3-F wherein Rf^3 is a C_{5-16} perfluoroalkyl group. The fluorine-containing oil may be a chlorotrifluoroethylene oligomer.

[0178] The fluorine-containing oil may have an average molecular weight of 500 to 10,000. The molecular weight of the fluorine-containing oil may be measured using gel permeation chromatography (GPC).

[0179] The fluorine-containing oil may be contained in an amount of, for example, 0 to 50 mass%, preferably 0 to 30 mass%, and more preferably 0 to 5 mass%, based on the composition of the present disclosure. In one embodiment, the composition of the present disclosure is substantially free of the fluorine-containing oil. Being substantially free of the fluorine-containing oil means that the fluorine-containing oil is not contained at all, or an extremely small amount of the fluorine-containing oil may be contained.

[0180] The fluorine-containing oil contributes to increasing the surface slickness of a layer formed of the composition of the present disclosure.

[0181] For example, the silicone oil may be linear or cyclic silicone oil having 2,000 or fewer siloxane bonds. The linear silicone oil may be so-called straight silicone oil or modified silicone oil. Examples of the straight silicone oil include dimethyl silicone oil, methyl phenyl silicone oil, and methyl hydrogen silicone oil. Examples of the modified silicone oil

include those obtained by modifying straight silicone oil with alkyl, aralkyl, polyether, higher fatty acid ester, fluoroalkyl, amino, epoxy, carboxyl, alcohol, or the like. Examples of the cyclic silicone oil include cyclic dimethylsiloxane oil.

[0182] In the composition of the present disclosure (for example, a surface-treating agent), such silicone oil may be contained in an amount of, for example, 0 to 300 parts by mass, and preferably 50 to 200 parts by mass, based on total 100 parts by mass of the fluoropolyether group-containing silane compound of the present disclosure (in the case of two or more kinds, the total thereof, and the same applies below).

[0183] Silicone oil contributes to increasing the surface slickness of the surface-treating layer.

[0184] Examples of the catalyst include acids (such as acetic acid and trifluoroacetic acid), bases (such as ammonia, triethylamine, and diethylamine), and transition metals (such as Ti, Ni, and Sn).

[0185] The catalyst promotes hydrolysis and dehydrative condensation of the fluoropolyether group-containing silane compound of the present disclosure, and promotes formation of a layer formed of the composition of the present disclosure (for example, a surface-treating agent).

[0186] Examples of other components include, in addition to those described above, tetraethoxysilane, methyltrimethoxysilane, 3-aminopropyltrimethoxysilane, 3-glycidoxypropyltrimethoxysilane, and methyltriacetoxysilane.

[0187] The composition of the present disclosure can be used as a surface-treating agent for surface treatment of a substrate.

[0188] The surface-treating agent of the present disclosure can be formed into pellets by impregnating with the composition a porous material such as a porous ceramic material or a metal fiber such as a fiber obtained by, for example, solidifying steel wool in a cotton-like form. Such pellets can be used in, for example, vacuum deposition.

[0189] Below, the article of the present disclosure will now be described.

[0190] The article of the present disclosure contains a substrate and a layer (such as a surface-treating layer) on the surface of the substrate, wherein the layer is formed of the fluoropolyether group-containing silane compound of the present disclosure or a surface-treating agent containing the fluoropolyether group-containing silane compound (hereinafter, these are simply referred to as "the surface-treating agent of the present disclosure" collectively).

[0191] The substrate usable herein may be composed of any suitable material such as glass, resin (which may be natural or synthetic resin such as a commonly used plastic material, and may be in the form of a plate, a film, or the like), metal, ceramics, semiconductors (such as silicon and germanium), fiber (such as woven fabric and nonwoven fabric), fur, leather, wood, pottery, stone, and building materials.

[0192] For example, when the article to be produced is an optical member, the material constituting the surface of the substrate may be a material for an optical member, such as glass or a transparent plastic. When the article to be produced is an optical member, some layer (or film) such as a hard coat layer or an antireflection layer may be formed on the surface (the outermost layer) of the substrate. The antireflection layer may be any of a single-layer antireflection layer and a multi-layer antireflection layer. Examples of inorganic substances usable in the antireflection layer include SiO_2 , SiO , ZrO_2 , TiO_2 , TiO , Ti_2O_3 , Ti_2O_5 , Al_2O_3 , Ta_2O_5 , CeO_2 , MgO , Y_2O_3 , SnO_2 , MgF_2 , and WO_3 . One of these inorganic substances may be used singly, or two or more may be used in combination (e.g., as a mixture). In the case of a multi-layer antireflection layer, SiO_2 and/or SiO is preferably used in the outermost layer thereof. When the article to be produced is an optical glass component for a touch panel, a part of the surface of the substrate (glass) may have a transparent electrode such as a thin film in which indium tin oxide (ITO), indium zinc oxide, or the like is used. The substrate, according to its specific configuration or the like, may have an insulating layer, an adhesive layer, a protecting layer, a decorated frame layer (I-CON), an atomizing film layer, a hard coating layer, a polarizing film, a phase difference film, a liquid crystal display module, or the like.

[0193] The shape of the substrate is not limited. The surface region of the substrate on which a surface-treating layer is to be formed is at least a part of the substrate surface, and may be suitably determined according to the application, specific configuration, and the like of an article to be produced.

[0194] The substrate, or at least the surface portion thereof, may be composed of a material originally having a hydroxyl group. Examples of the material include glass as well as metal (in particular, base metal) wherein a natural oxidized film or a thermal oxidized film is formed on the surface, ceramics, semiconductors, and the like. Alternatively, when the substrate has an insufficient amount of a hydroxyl group or when the substrate originally does not have a hydroxyl group as in resin and the like, a pre-treatment may be performed on the substrate to thereby introduce or increase a hydroxyl group on the surface of the substrate. Examples of such a pre-treatment include a plasma treatment (e.g., corona discharge) and ion beam irradiation. The plasma treatment can be suitably utilized to not only introduce or increase a hydroxyl group on the substrate surface, but also clean the substrate surface (remove foreign matter and the like). Another example of such a pre-treatment includes a method wherein a monolayer of a surface adsorbent having a carbon-carbon unsaturated bonding group is formed on the surface of the substrate by a LB method (a Langmuir-Blodgett method), a chemical adsorption method, or the like beforehand, and, thereafter, cleaving the unsaturated bond under an atmosphere containing oxygen, nitrogen, or the like.

[0195] Alternatively, the substrate, or at least on a surface portion thereof, may be composed of a silicone compound having one or more other reactive groups such as a Si-H group, or a material containing alkoxy silane.

[0196] Then, a layer of the surface-treating agent of the present disclosure is formed on the surface of the substrate, this layer is post-treated as necessary, and thereby a layer is formed from the surface-treating agent of the present disclosure.

[0197] The layer of the surface-treating agent of the present disclosure can be formed by applying the above composition on the surface of the substrate such that the composition coats the surface. The coating method is not limited. For example, a wet coating method and a dry coating method can be used.

[0198] Examples of the wet coating method include dip coating, spin coating, flow coating, spray coating, roll coating, gravure coating, and similar methods.

[0199] Examples of the dry coating method include deposition (usually, vacuum deposition), sputtering, CVD, and similar methods. Specific examples of the deposition method (usually, a vacuum deposition method) include resistive heating, electron beam, high-frequency heating using microwave or the like, ion beam, and similar methods. Specific examples of the CVD method include plasma-CVD, optical CVD, thermal CVD, and similar methods.

[0200] Furthermore, coating by an atmospheric pressure plasma method can be performed.

[0201] When using the wet coating method, the surface-treating agent of the present disclosure may be applied to the substrate surface after being diluted with a solvent. From the viewpoint of the stability of the composition of the present disclosure and the volatility of solvents, the following solvents are preferably used: perfluoroaliphatic hydrocarbons having 5 to 12 carbon atoms (such as perfluorohexane, perfluoromethylcyclohexane, and perfluoro-1,3-dimethylcyclohexane); polyfluoroaromatic hydrocarbons (such as bis(trifluoromethyl)benzene); polyfluoroaliphatic hydrocarbons (such as $C_6F_{13}CH_2CH_3$ (such as Asahiklin (registered trademark) AC-6000 manufactured by Asahi Glass Co., Ltd., and 1,1,2,2,3,3,4-heptafluorocyclopentane (such as Zeorora (registered trademark) H manufactured by Zeon Corporation)); alkyl perfluoroalkyl ethers (the perfluoroalkyl group and the alkyl group may be linear or branched) such as hydrofluoroether (HFE) (such as perfluoropropylmethyl ether ($C_3F_7OCH_3$) (such as Novec (trademark) 7000 manufactured by Sumitomo 3M Limited), perfluorobutyl methyl ether ($C_4F_9OCH_3$) (such as Novec (trademark) 7100 manufactured by Sumitomo 3M Limited), perfluorobutyl ethyl ether ($C_4F_9OC_2H_5$) (such as Novec (trademark) 7200 manufactured by Sumitomo 3M Limited), and perfluorohexyl methyl ether ($C_2F_5CF(OCH_3)C_3F_7$) (such as Novec (trademark) 7300 manufactured by Sumitomo 3M Limited), or $CF_3CH_2OCF_2CHF_2$ (such as Asahiklin (registered trademark) AE-3000 manufactured by Asahi Glass Co., Ltd.)). One of these solvents can be used singly, or two or more can be used as a mixture. In particular, hydrofluoroether is preferable, and perfluorobutyl methyl ether ($C_4F_9OCH_3$) and/or perfluorobutyl ethyl ether ($C_4F_9OC_2H_5$) is particularly preferable.

[0202] When using the dry coating method, the surface-treating agent of the present disclosure may be directly subjected to the dry coating method, or may be diluted with the above solvent before being subjected to the dry coating method.

[0203] A layer of the surface-treating agent is preferably formed such that the surface-treating agent of the present disclosure coexists with a catalyst for hydrolysis and dehydrative condensation in the layer. Conveniently, in the case of a wet coating method, the surface-treating agent of the present disclosure is diluted with a solvent, and then, immediately before application to the substrate surface, a catalyst may be added to the diluted solution of the surface-treating agent of the present disclosure. In the case of a dry coating method, the surface-treating agent of the present disclosure to which a catalyst has been added is directly used in a deposition (usually vacuum deposition) treatment, or a pellet-like material may be used in a deposition (usually vacuum deposition) treatment, wherein the pellets are obtained by impregnating a porous body of metal such as iron or copper with the surface-treating agent of the present disclosure to which a catalyst has been added.

[0204] The catalyst may be any suitable acid or base. The acid catalyst may be, for example, acetic acid, formic acid, or trifluoroacetic acid. The base catalyst may be, for example, ammonia or organic amine.

[0205] In the above-described manner, a layer derived from the surface-treating agent of the present disclosure is formed on the substrate surface, and the article of the present disclosure is produced. The layer thus obtained has both high surface slickness and high friction durability. The layer may have not only high friction durability but also have, depending on the formulation of the surface-treating agent used, water-repellency, oil-repellency, antifouling properties (for example, preventing grime such as fingerprints from adhering), waterproof properties (preventing water from entering electronic components and the like), surface slickness (or lubricity, such as removability by wiping of grime such as fingerprints, and excellent tactile sensations), and the like, and may be suitably used as a functional thin film.

[0206] That is to say, the present disclosure further relates to an optical material having the cured product in the outermost layer.

[0207] The optical material preferably includes a wide variety of optical materials in addition to optical materials relating to displays and the like as exemplified below: for example, displays such as cathode ray tubes (CRTs; e.g., PC monitors), liquid crystal displays, plasma displays, organic EL displays, inorganic thin-film EL dot matrix displays, rear projection displays, vacuum fluorescent displays (VFDs), field emission displays (FEDs); protective plates for such displays; and those obtained by performing an antireflection film treatment on their surfaces.

[0208] The article having a layer obtained according to the present disclosure may be, but is not limited to, an optical

member. Examples of the optical member include lenses of glasses or the like; front surface protective plates, antireflection plates, polarizing plates, and anti-glare plates for displays such as PDPs and LCDs; touch panel sheets for devices such as mobile phones and personal digital assistants; disc surfaces of optical discs such as Blu-ray (registered trademark) discs, DVD discs, CD-Rs, and MOs; optical fibers; and display surfaces of watches and clocks.

[0209] The article having a layer obtained according to the present disclosure may be an automobile interior/exterior material. Examples of exterior materials include windows, light covers, and aftermarket camera covers. Examples of interior materials include instrument panel covers, navigation system touch panels, and decorative interior materials.

[0210] The article having a layer obtained according to the present disclosure may be medical equipment or a medical material.

[0211] The thickness of the layer is not limited. The thickness of the layer in the case of an optical member is in the range of 1 to 50 nm, 1 to 30 nm, and preferably 1 to 15 nm, from the viewpoint of optical performance, surface slickness, friction durability, and antifouling properties.

[0212] Embodiments have been described above, but it will be understood that various modifications can be made to embodiments and details without departing from the spirit and the scope of the claims.

Examples

[0213] The present disclosure will now be described more specifically by way of the Examples below, but the present disclosure is not limited to the Examples. In the Examples, all chemical formulae shown below indicate average compositions, and the occurrence order of repeating units (such as (OCF_2CF_2) and (OCF_2)) constituting perfluoropolyether is not limited.

(Synthetic Example 1)

[0214] First, 4.0 g of $CF_3-(OCF_2CF_2)_m-(OCF_2)_n-CH_2OH$ ($m \approx 18$, $n \approx 18$) was dispersed in a mixed solvent of 3.0 g of 1,3-bis(trifluoromethyl)benzene and 2.0 g of diethylene glycol dimethyl ether. To the dispersion was added 0.4 g of sodium hydroxide, and the mixture was stirred at 80°C for 2 hours. To the mixture was added dropwise 0.5 g of bromoacetic acid dissolved in 2.0 g of diethylene glycol dimethyl ether while vigorously stirring the mixture, and then the mixture was stirred at 80°C for 3 hours. The end point of the reaction was confirmed by ^{19}F -NMR according to that the chemical shift of $-CF_2-$ at the hydroxyl group β position of $CF_3-(OCF_2CF_2)_m-(OCF_2)_n-CH_2OH$ shifted to a low magnetic field, and by 1H -NMR according to that the methylene proton at the carbonyl group α position of bromoacetic acid shifted to a high magnetic field. The reaction solution, when being cooled to room temperature, separated into a liquid phase and a solid phase. After the liquid phase was removed, 10 g of AK-225 was added to the solid phase, and 10 g of a 10 wt% aqueous sulfuric acid solution was added while stirring the mixture. After being stirred for 20 minutes, the mixture was left to stand still, the lower phase was separated, and the separated lower phase was washed with water twice, dried over magnesium sulfate, and concentrated. The resulting concentrate was dissolved in perfluorohexane. The solution was washed with acetone three times, and thus a polyether group-containing compound (A) was obtained.

[0215] Polyether group-containing compound (A):

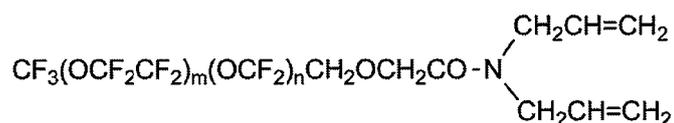


($m \approx 18$, $n \approx 18$)

(Synthetic Example 2)

[0216] First, 3.0 g of the polyether group-containing compound (A) obtained in Synthetic Example 1 was dissolved in 5.0 g of 1,3-bis(trifluoromethyl)benzene, and ice-cooled. After 0.3 g of thionyl chloride was added dropwise to the solution, 0.01 mg of N,N-dimethylformamide was added, and the mixture was stirred at room temperature for 24 hours. After thionyl chloride was distilled off from this reaction solution, 0.18 g of diallylamine and 0.2 g of triethylamine were added, and the mixture was heated to 50°C and stirred for 3 hours. The end point of the reaction was confirmed by ^{19}F -NMR according to that the chemical shift of $-CF_2-$ at the ether group β position of $CF_3-(OCF_2CF_2)_m-(OCF_2)_n-CH_2O-$ shifted to a low magnetic field, and by 1H -NMR according to that the methylene proton at the amino group α -position of diallylamine shifted to a low magnetic field. The lower phase separated by adding 1 N hydrochloric acid to the reaction solution was washed with water, dried over magnesium sulfate, and concentrated. The resulting concentrate was dissolved in perfluorohexane and washed with acetone three times, and thus a polyether group-containing compound (B) was obtained.

[0217] Polyether group-containing compound (B):



5

(m≈18, n≈18)

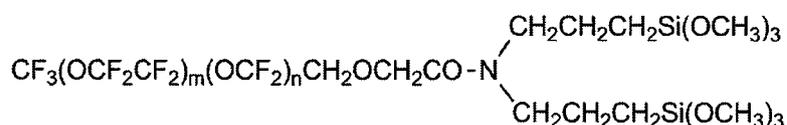
(Synthetic Example 3)

10 **[0218]** First, 3.0 g of the polyether group-containing compound (B) obtained in Synthetic Example 2 was dissolved in 6 g of 1,3-bis(trifluoromethyl)benzene, then 0.02 g of triacetoxymethylsilane and 0.04 ml of a xylene solution containing a 2% Pt complex of 1,3-divinyl-1,1,3,3-tetramethyldisiloxane were added, 0.8 g of trichlorosilane was added, and the mixture was stirred at 10°C for 30 minutes. Subsequently, the resulting reaction solution was heated to 60°C and stirred for 4 hours. Thereafter, volatiles were distilled off under reduced pressure, then a mixed solution of 0.1 g of methanol and 2.0 g of trimethyl orthoformate was added, and the mixture was heated to 60°C and stirred for 3 hours. Thereafter, purification was performed, and thus 2.9 g of the following polyether group-containing compound (C) having trimethoxysilyl groups at terminals was obtained.

15

[0219] Polyether group-containing compound (C):

20



25

(m≈18, n≈18)

(Synthetic Example 4)

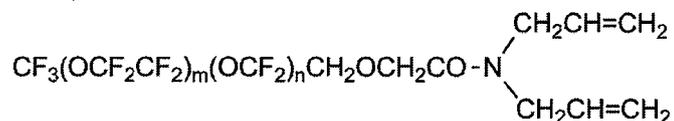
30 **[0220]** First, 4.0 g of $\text{CF}_3(\text{OCF}_2\text{CF}_2)_m(\text{OCF}_2)_n\text{CH}_2\text{OH}$ (m≈18, n≈18) was dispersed in a mixed solvent of 3.0 g of 1,3-bis(trifluoromethyl)benzene and 2.0 g of diethylene glycol dimethyl ether. Then 0.4 g of sodium hydroxide was added, and the mixture was stirred at 80°C for 2 hours. To the mixture was added dropwise 0.5 g of N,N'-diallyl-2-chloroacetic acid amide ($\text{ClCH}_2\text{CON}(\text{CH}_2\text{CH}=\text{CH}_2)_2$) dissolved in 2.0 g of diethylene glycol dimethyl ether while vigorously stirring the mixture, and then the mixture was stirred at 80°C for 3 hours. The end point of the reaction was confirmed by ¹⁹F-NMR according to that the chemical shift of -CF₂- at the hydroxyl group β position of $\text{CF}_3(\text{OCF}_2\text{CF}_2)_m(\text{OCF}_2)_n\text{CH}_2\text{OH}$ shifted to a low magnetic field, and by ¹H-NMR according to that the methylene proton at the carbonyl group α position of chloroacetic acid shifted to a high magnetic field. The reaction solution was cooled to room temperature, and 10 g of 1 N hydrochloric acid was added while stirring the solution. After being stirred for 5 minutes, the mixture was left to stand still, and the lower phase was separated, washed with water twice, dried over magnesium sulfate, and concentrated. The resulting concentrate was dissolved in perfluorohexane and washed with acetone three times, and thus a polyether group-containing compound (D) was obtained.

35

40

[0221] Polyether group-containing compound (D):

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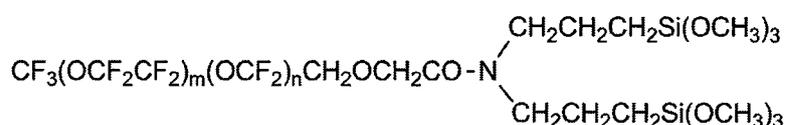


(m≈18, n≈18)

50 **[0222]** The same operations as in Synthetic Example 3 were carried out except that 3.0 g of the resulting polyether group-containing compound (D) was used, and thus 3.1 g of a polyether group-containing compound (E) was obtained.

[0223] Polyether group-containing compound (E):

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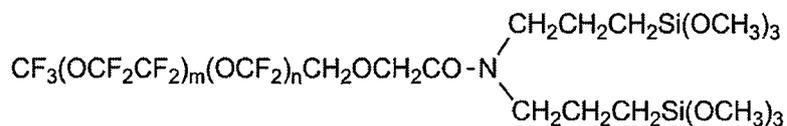
(m≈18, n≈18)

(Synthetic Example 5)

5 **[0224]** The same operations as in Synthetic Example 4 were carried out except that 6.0 g of $\text{CF}_3\text{-(OCF}_2\text{CF}_2)_m\text{-(OCF}_2)_n\text{-CH}_2\text{OH}$ (m≈33, n≈32) was used, and thus 5.8 g of a polyether group-containing compound (F) was obtained.

[0225] Polyether group-containing compound (F):

10



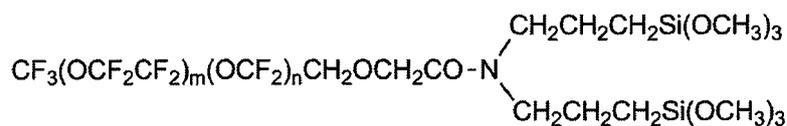
15 (m≈33, n≈32)

(Synthetic Example 6)

20 **[0226]** The same operations as in Synthetic Example 4 were carried out except that 6.0 g of $\text{CF}_3\text{-(OCF}_2\text{CF}_2)_m\text{-(OCF}_2)_n\text{-CH}_2\text{OH}$ (m≈17, n≈29) was used, and thus 6.1 g of a polyether group-containing compound (G) was obtained.

[0227] Polyether group-containing compound (G):

25



(m≈17, n≈29)

30

(Example 1)

35 **[0228]** The polyether group-containing compound (E) obtained in Synthetic Example 4 was dissolved in hydrofluoroether (Novec HFE-7200, manufactured by 3M) so as to have a concentration of 0.1 mass%, and thus a surface-treating agent (1) was prepared.

(Example 2)

40 **[0229]** The polyether group-containing compound (F) obtained in Synthetic Example 5 was dissolved in hydrofluoroether (Novec HFE-7200, manufactured by 3M) so as to have a concentration of 0.1 mass%, and thus a surface-treating agent (2) was prepared.

(Example 3)

45 **[0230]** The polyether group-containing compound (G) obtained in Synthetic Example 6 was dissolved in hydrofluoroether (Novec HFE-7200, manufactured by 3M) so as to have a concentration of 0.1 mass%, and thus a surface-treating agent (3) was prepared.

(Comparative Examples 1 and 2)

50

[0231] Comparative surface-treating agents (1) and (2) were prepared in the same manner as in Example 2 except that the following control compounds (1) and (2) were used, respectively, in place of the polyether group-containing compound (F).

55

	Control	Compound
(1)	$\text{CF}_3\text{CF}_2\text{CF}_2\text{-(OCF}_2\text{CF}_2\text{CF}_2)_2\text{-OCF}_2\text{CF}_2\text{CH}_2\text{OCH}_2\text{CH}_2\text{CH}_2\text{Si}(\text{OCH}_3)_3$	
	Control Compound (2)	$\text{CF}_3\text{CF}_2\text{CF}_2\text{CF}_2\text{CF}_2\text{CF}_2\text{CH}_2\text{CH}_2\text{Si}(\text{OCH}_2\text{CH}_3)_3$

(Static contact angle)

5 **[0232]** The static contact angle was measured by the following method using a fully automatic contact angle meter DropMaster 700 (manufactured by Kyowa Interface Science Co., Ltd.).

<Method for measuring static contact angle>

10 **[0233]** The static contact angle was obtained by dripping 2 μ L of water from a microsyringe onto a horizontally placed substrate and taking a still image with a video microscope 1 second after the dripping.

(Formation of cured film)

15 **[0234]** The surface-treating agents (1) to (3) and the comparative surface-treating agents (1) to (2) were used to form cured films as follows (surface-treating layers).

[0235] A surface-treating agent or a comparative surface-treating agent was applied to a chemically tempered glass ("Gorilla" glass, manufactured by Corning Incorporated, thickness 0.7 mm) using a spin coater.

The spin coating conditions were 300 rpm for 3 seconds and 2,000 rpm for 30 seconds.

20 The coated glass was heated at 150°C for 30 minutes in a thermostatic oven in air to form a cured film.

[Evaluation of cured film properties]

[0236] Properties of the resulting cured film were evaluated as follows.

25

<Static contact angle>

(Initial evaluation)

30 **[0237]** First, as an initial evaluation, after the formation of the cured film, the static water contact angle of the surface with which nothing had been brought into contact yet was measured.

(Evaluation after wiping with ethanol)

35 **[0238]** The cured film was wiped back and forth five times with Kimwipe (trade name, manufactured by Jujo Kimberly Co., Ltd.) sufficiently soaked with ethanol, and dried. The static water contact angle of the cured film after being dried was measured.

<Fingerprint adherability and removability by wiping>

40

(Fingerprint adherability)

[0239] A finger was pressed against a cured film formed using a surface-treating agent or a comparative surface-treating agent, and how easily a fingerprint adhered was visually judged. Evaluations were made according to the following criteria:

45

A: Fingerprint unlikely adhered, or not noticeable even when adhered.

B: Adhered fingerprint was little, but fingerprint sufficiently confirmed.

C: Fingerprint adhered as clearly as fingerprint on untreated glass substrate.

50

(Fingerprint removability by wiping)

[0240] After the fingerprint adherability test, the adhered fingerprint was wiped back and forth five times with Kimwipe (trade name, manufactured by Jujo Kimberly Co., Ltd.), and how easily the adhered fingerprint was wiped off was visually judged. Evaluations were made according to the following criteria:

55

A: Fingerprint completely wiped off.

B: Fingerprint wiping marks remained.

C: Fingerprint wiping marks spread, and difficult to remove.

5 [0241] The results of the series of evaluations are summarized in Table 1 below.

[Table 1]

Treating agent		Contact angle (degree)		Fingerprint adherability and removability by wiping		
		Initial evaluation	After wiping with ethanol	Fingerprint adherability	Fingerprint removability by wiping	
10						
15	Surface-treating agent (1)	Example 1	113	113	A	A
	Surface-treating agent (2)	Example 2	114	114	A	A
20	Surface-treating agent (3)	Example 3	115	115	A	A
	Comparative surface-treating agent (1)	Comparative Example 1	113	112	A	B
25	Comparative surface-treating agent (2)	Comparative Example 2	105	103	B	C

30 [0242] The contact angles of the cured films formed using the surface-treating agents (1) to (3) did not decrease even when the films were wiped using ethanol. On the other hand, the contact angles of the cured films formed using the comparative surface-treating agents (1) and (2) decreased when the films were wiped using ethanol. This is considered to be because the cured films formed of the comparative surface-treating agents (1) and (2) have poor chemical resistance (durability against solvent).

35 [Evaluation of friction durability of cured films]

[0243] The friction durability of the resulting cured films was evaluated as follows.

<Eraser friction durability test>

40 [0244] Using a rubbing tester (manufactured by Shinto Scientific Co., Ltd.), the contact angle with water was measured every 2,500 times of rubbing under the following conditions, and the test was continued until reaching 10,000 times or a contact angle of less than 100 degrees. The test environment conditions were 25°C and a humidity of 40% RH.

45 Eraser: Raber Eraser (manufactured by Minoan)

Ground contact area: 6 mmφ

Travel distance (one way): 30 mm

Travel speed: 3,600 mm/min

Load: 1 kg/6 mmφ

50 [0245] The results of the above evaluation are summarized in Table 2 below. In the table, "-" means that no measurement was performed.

55

[Table 2]

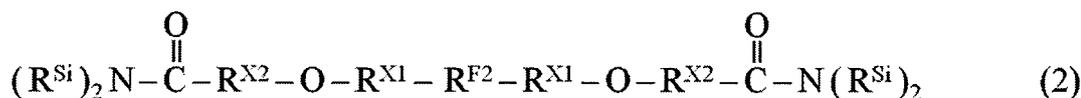
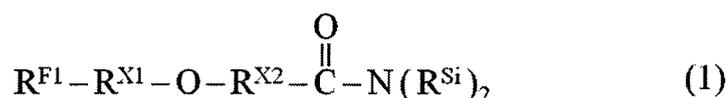
Treating agent		Number of times eraser was rubbed				
		0 times	2,500 times	5,000 times	7,500 times	10,000 times
Surface-treating agent (1)	Example 1	113	113	112	110	105
Surface-treating agent (2)	Example 2	114	113	111	108	106
Surface-treating agent (3)	Example 3	115	114	112	109	101
Comparative surface-treating agent (1)	Comparative Example 1	113	89	-	-	-

Industrial Applicability

[0246] The fluoropolyether group-containing compound of the present disclosure can be suitably used to form a surface-treating layer on the surfaces of a wide variety of substrates or, in particular, optical members that require friction durability.

Claims

1. A fluoropolyether group-containing compound of formula (1) or (2) below:



wherein

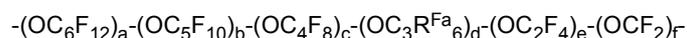
R^{F1} is R^{f1}-R^F-O_q-;

R^{F2} is -R^{f2}_p-R^F-O_q-;

R^{f1} is a C₁₋₁₆ alkyl group optionally substituted with one or more fluorine atoms;

R^{f2} is a C₁₋₆ alkylene group optionally substituted with one or more fluorine atoms;

R^F is each independently at each occurrence a group represented by formula:



a, b, c, d, e, and f are each independently an integer of 0 to 200, and the sum of a, b, c, d, e, and f is 1 or more, and the occurrence order of each repeating unit enclosed in parentheses provided with a, b, c, d, e, or f is not limited in the formula;

R^{Fa} is each independently at each occurrence a hydrogen atom, a fluorine atom, or a chlorine atom;

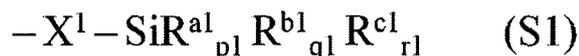
p is 0 or 1;

q is independently 0 or 1;

R^{X1} is each independently at each occurrence a C₁₋₆ alkylene group;

R^{X2} is each independently at each occurrence a C₁₋₆ alkylene group optionally substituted with a C₁₋₆ alkyl group or cyclic alkyl group optionally containing one or more nitrogen atoms, oxygen atoms, sulfur atoms, or silicon atoms, or with a perfluoroalkyl group;

R^{Si} is each independently at each occurrence represented by formula (S1) below:



5 X¹ is each independently at each occurrence a single bond, an oxygen atom, or a divalent organic group;
 R^{a1} is each independently at each occurrence -Z¹-SiR^{a1'}_{p1'}R^{b1'}_{q1'}R^{c1'}_{r1'};
 Z¹ is each independently at each occurrence a single bond, an oxygen atom, or a divalent organic group;
 R^{a1'} is each independently at each occurrence -Z^{1''}-SiR^{a1''}_{p1''}R^{b1''}_{q1''}R^{c1''}_{r1''};
 10 Z^{1''} is each independently at each occurrence a single bond, an oxygen atom, or a divalent organic group;
 R^{a1''} is each independently at each occurrence -Z^{1'''}-SiR^{a1'''}_{p1'''}R^{b1'''}_{q1'''}R^{c1'''}_{r1'''};
 Z^{1'''} is each independently at each occurrence a single bond, an oxygen atom, or a divalent organic group;
 R^{b1'''} is each independently at each occurrence a hydroxyl group or a hydrolyzable group;
 R^{c1'''} is each independently at each occurrence a hydrogen atom or a monovalent organic group;
 q1''' is each independently at each occurrence an integer of 0 to 3;
 15 r1''' is each independently at each occurrence an integer of 0 to 3;
 R^{b1''} is each independently at each occurrence a hydroxyl group or a hydrolyzable group;
 R^{c1''} is each independently at each occurrence a hydrogen atom or a monovalent organic group;
 p1'' is each independently at each occurrence an integer of 0 to 3;
 q1'' is each independently at each occurrence an integer of 0 to 3;
 20 r1'' is each independently at each occurrence an integer of 0 to 3;
 R^{b1'} is each independently at each occurrence a hydroxyl group or a hydrolyzable group;
 R^{c1'} is each independently at each occurrence a hydrogen atom or a monovalent organic group;
 p1' is each independently at each occurrence an integer of 0 to 3;
 q1' is each independently at each occurrence an integer of 0 to 3;
 25 r1' is each independently at each occurrence an integer of 0 to 3;
 R^{b1} is each independently at each occurrence a hydroxyl group or a hydrolyzable group;
 R^{c1} is each independently at each occurrence a hydrogen atom or a monovalent organic group;
 p1 is each independently at each occurrence an integer of 0 to 3;
 q1 is each independently at each occurrence an integer of 0 to 3;
 30 r1 is each independently at each occurrence an integer of 0 to 3; and
 at least one R^{b1}, R^{b1'}, R^{b1''}, or R^{b1'''} is present for each group represented by R^{Si}.

2. The fluoropolyether group-containing compound according to claim 1, wherein p1 is 0, and q1 is 2 or 3.
- 35 3. The fluoropolyether group-containing compound according to claim 1 or 2, wherein R^{Fa} is a fluorine atom.
4. The fluoropolyether group-containing compound according to any one of claims 1 to 3, wherein X¹ is each independently at each occurrence a divalent organic group.
- 40 5. The fluoropolyether group-containing compound according to any one of claims 1 to 4, wherein X¹ is each independently at each occurrence -(Z²¹)_{z11}-(X²)_{z12}-(Z²²)_{z13}-wherein Z²¹ and Z²² are a divalent organic group;

X² is an oxygen atom;
 z11 is 0 or 1;
 45 z12 is 0 or 1;
 z13 is 0 or 1; and
 at least one of z11 and z13 is 1.
- 50 6. The fluoropolyether group-containing compound according to any one of claims 1 to 5, wherein X¹ is each independently at each occurrence an alkylene group.
7. A surface-treating agent comprising the fluoropolyether group-containing compound according to any one of claims 1 to 6.
- 55 8. The surface-treating agent according to claim 7, further comprising one or more other components selected from a fluorine-containing oil, a silicone oil, and a catalyst.
9. The surface-treating agent according to claim 7 or 8, further comprising a solvent.

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10. The surface-treating agent according to any one of claims 7 to 9, which is used as an antifouling coating agent or a water-proof coating agent.

5

11. The surface-treating agent according to any one of claims 7 to 10, which is for vacuum deposition.

12. A pellet comprising the surface treatment agent according to any one of claims 7 to 10.

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13. An article comprising a substrate and a layer on a surface of the substrate, wherein the layer is formed of the compound according to any one of claims 1 to 6 or the surface-treating agent according to any one of claims 7 to 11.

14. The article according to claim 13, which is an optical member.

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INTERNATIONAL SEARCH REPORT

International application No.

PCT/JP2020/013783

A. CLASSIFICATION OF SUBJECT MATTER		
Int. Cl. C08G65/336 (2006.01) i, C09D5/16 (2006.01) i, C09D171/00 (2006.01) i, C09K3/18 (2006.01) i FI: C08G65/336, C09K3/18 104, C09D171/00, C09D5/16 According to International Patent Classification (IPC) or to both national classification and IPC		
B. FIELDS SEARCHED		
Minimum documentation searched (classification system followed by classification symbols) Int. Cl. C08G65/336, C09D5/16, C09D171/00, C09K3/18		
Documentation searched other than minimum documentation to the extent that such documents are included in the fields searched Published examined utility model applications of Japan 1922-1996 Published unexamined utility model applications of Japan 1971-2020 Registered utility model specifications of Japan 1996-2020 Published registered utility model applications of Japan 1994-2020		
Electronic data base consulted during the international search (name of data base and, where practicable, search terms used) CAplus/REGISTRY (STN)		
C. DOCUMENTS CONSIDERED TO BE RELEVANT		
Category*	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
A	WO 2009/008380 A1 (ASAHI GLASS CO., LTD.) 15 January 2009, entire text	1-14
A	JP 2002-121277 A (SHIN-ETSU CHEMICAL CO., LTD.) 23 April 2002, entire text	1-14
A	JP 2017-121787 A (CANON INC.) 13 July 2017, entire text	1-14
A	JP 2017-154055 A (CANON INC.) 07 September 2017, entire text	1-14
A	JP 2000-327772 A (SHIN-ETSU CHEMICAL CO., LTD.) 28 November 2000, entire text	1-14
<input checked="" type="checkbox"/> Further documents are listed in the continuation of Box C.		<input checked="" type="checkbox"/> See patent family annex.
* Special categories of cited documents: "A" document defining the general state of the art which is not considered to be of particular relevance "E" earlier application or patent but published on or after the international filing date "L" document which may throw doubts on priority claim(s) or which is cited to establish the publication date of another citation or other special reason (as specified) "O" document referring to an oral disclosure, use, exhibition or other means "P" document published prior to the international filing date but later than the priority date claimed		"I" later document published after the international filing date or priority date and not in conflict with the application but cited to understand the principle or theory underlying the invention "X" document of particular relevance; the claimed invention cannot be considered novel or cannot be considered to involve an inventive step when the document is taken alone "Y" document of particular relevance; the claimed invention cannot be considered to involve an inventive step when the document is combined with one or more other such documents, such combination being obvious to a person skilled in the art "&" document member of the same patent family
Date of the actual completion of the international search 08.06.2020		Date of mailing of the international search report 16.06.2020
Name and mailing address of the ISA/ Japan Patent Office 3-4-3, Kasumigaseki, Chiyoda-ku, Tokyo 100-8915, Japan		Authorized officer Telephone No.

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INTERNATIONAL SEARCH REPORT

International application No.
PCT/JP2020/013783

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C (Continuation). DOCUMENTS CONSIDERED TO BE RELEVANT		
Category*	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
A	JP 2014-205739 A (CANON INC.) 30 October 2014, entire text	1-14
P, X	WO 2019/203320 A1 (AGC INC.) 24 October 2019, claims, paragraphs [0141]-[0143], [0150], [0167]- [0169], examples	1-14

INTERNATIONAL SEARCH REPORT
Information on patent family members

International application No.
PCT/JP2020/013783

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JP 2017-154055 A	07.09.2017	US 2017/0247571 A1 entire text	
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WO 2019/203320 A1	24.10.2019	(Family: none)	

REFERENCES CITED IN THE DESCRIPTION

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